

CPC COOPERATIVE PATENT CLASSIFICATION

H ELECTRICITY

(NOTE omitted)

H01 BASIC ELECTRIC ELEMENTS

(NOTES omitted)

H01J ELECTRIC DISCHARGE TUBES OR DISCHARGE LAMPS (spark-gaps [H01T](#); arc lamps with consumable electrodes [H05B](#); particle accelerators [H05H](#))

NOTES

1. This subclass covers only devices for producing, influencing, or using a flow of electrons or ions, e.g. for controlling, indicating, or switching of electric current, counting electric pulses, producing light or other electromagnetic oscillations, such as X-rays, or for separating or analysing radiation or particles, and having a closed or substantially closed casing containing a chosen gas, vapour, or vacuum, upon the pressure and nature of which the characteristics of the device depend. Light sources using a combination (other than covered by group [H01J 61/96](#) of this subclass) of discharge and other kinds of light generation are dealt with in [H05B 35/00](#).
2. In this subclass, groups [H01J 1/00](#) - [H01J 7/00](#) relate only to:
 - i. details of an unspecified kind of discharge tube or lamp, or
 - ii. details mentioned in a specification as applicable to two or more kinds of tubes or lamps as defined by groups [H01J 11/00](#), [H01J 13/00](#), [H01J 15/00](#), [H01J 17/00](#), [H01J 21/00](#), [H01J 25/00](#), [H01J 27/00](#), [H01J 31/00](#), [H01J 33/00](#), [H01J 35/00](#), [H01J 37/00](#), [H01J 40/00](#), [H01J 41/00](#), [H01J 47/00](#), [H01J 49/00](#), [H01J 61/00](#), [H01J 63/00](#) or [H01J 65/00](#), hereinafter called basic kinds. A detail only described with reference to, or clearly only applicable to, tubes or lamps of a single basic kind is classified in the detail group appropriate to tubes or lamps of that basic kind, e.g. [H01J 17/04](#).
3. In this subclass, the following term is used with the meaning indicated:
 - "lamp" includes tubes emitting ultra-violet or infra-red light.
4. Attention is drawn to the definition of the expression "spark gaps" given in the Note following the title of subclass [H01T](#).
5. Apparatus or processes specially adapted for the manufacture of electric discharge tubes, discharge lamps, or parts thereof are classified in group [H01J 9/00](#).

WARNING

In this subclass non-limiting references (in the sense of paragraph 39 of the Guide to the IPC) may still be displayed in the scheme.

1/00	Details of electrodes, of magnetic control means, of screens, or of the mounting or spacing thereof, common to two or more basic types of discharge tubes or lamps (details of electron-optical arrangements or of ion traps H01J 3/00)	1/144 with other metal oxides as an emissive material
		1/146 with metals or alloys as an emissive material
		1/148 with compounds having metallic conductive properties, e.g. lanthanum boride, as an emissive material
1/02	. Main electrodes		
1/025	. . {Hollow cathodes}	1/15	. . . Cathodes heated directly by an electric current
1/04	. . Liquid electrodes, e.g. liquid cathode	1/16 characterised by the shape
1/05	. . . characterised by material	1/18 Supports; Vibration-damping arrangements
1/06	. . . Containers for liquid-pool electrodes; Arrangement or mounting thereof	1/20	. . . Cathodes heated indirectly by an electric current; Cathodes heated by electron or ion bombardment
1/08	. . . Positioning or moving the cathode spot on the surface of a liquid-pool cathode	1/22 Heaters
1/10	. . . Cooling, heating, circulating, filtering, or controlling level of liquid in a liquid-pool electrode	1/24 Insulating layer or body located between heater and emissive material
1/12	. . Cathodes having mercury or liquid alkali metal deposited on the cathode surface during operation of the tube	1/26 Supports for the emissive material
		1/28 Dispenser-type cathodes, e.g. L-cathode
		1/30	. . Cold cathodes, e.g. field-emissive cathode
1/13	. . Solid thermionic cathodes	1/304	. . . Field-emissive cathodes
1/135	. . . {Circuit arrangements therefor, e.g. for temperature control}	1/3042 {microengineered, e.g. Spindt-type}
		1/3044 {Point emitters}
		1/3046 {Edge emitters}
1/14	. . . characterised by the material	1/3048 {Distributed particle emitters}
1/142 with alkaline-earth metal oxides, or such oxides used in conjunction with reducing agents, as an emissive material	1/308	. . . Semiconductor cathodes, e.g. cathodes with PN junction layers

- 1/312 . . . having an electric field perpendicular to the surface, e.g. tunnel-effect cathodes of Metal-Insulator-Metal [MIM] type [{\(H01J 1/304 - H01J 1/308 take precedence\)}](#)
- 1/316 . . . having an electric field parallel to the surface, e.g. thin film cathodes
- 1/32 . . Secondary-electron-emitting electrodes [\(H01J 1/35 takes precedence\)](#)
- 1/34 . . Photo-emissive cathodes [\(H01J 1/35 takes precedence\)](#)
- 1/35 . . Electrodes exhibiting both secondary emission and photo-emission
- 1/36 . . Solid anodes; Solid auxiliary anodes for maintaining a discharge
- 1/38 . . . characterised by the material
- 1/40 . . . forming part of the envelope of the tube or lamp
- 1/42 . . . Cooling of anodes [\(cooling rotary anodes H01J 1/44\)](#); Heating of anodes
- 1/44 . . . Rotary anodes; Arrangements for rotating anodes; Cooling rotary anodes
- 1/46 . Control electrodes, e.g. grid [\(for igniting arrangements H01J 7/30\)](#); Auxiliary electrodes [\(auxiliary anodes for maintaining a discharge H01J 1/36\)](#)
- 1/48 . . characterised by the material
- 1/50 . Magnetic means for controlling the discharge
- 1/52 . Screens for shielding; Guides for influencing the discharge; Masks interposed in the electron stream
- 1/53 . Electrodes intimately associated with a screen on or from which an image or pattern is formed, picked up, converted, or stored [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/54 . Screens on or from which an image or pattern is formed, picked up, converted, or stored; Luminescent coatings on vessels [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/56 . . acting as light valves by shutter operation, e.g. for eidophor [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/58 . . acting by discolouration, e.g. halide screen [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/60 . . Incandescent screens [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/62 . . Luminescent screens; Selection of materials for luminescent coatings on vessels [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/63 . . . characterised by the luminescent material
- 1/64 . . . characterised by the binder or adhesive for securing the luminescent material to its supports [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/66 . . . Supports for luminescent material
- 1/68 . . . with superimposed luminescent layers [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/70 . . . with protective, conductive, or reflective layers [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/72 . . . with luminescent material discontinuously arranged, e.g. in dots or lines [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/74 . . . with adjacent dots or lines of different luminescent material [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/76 . . . provided with permanent marks or references [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/78 . . Photoelectric screens; Charge-storage screens [{\(see provisionally also H01J 29/08 - H01J 29/36\)}](#)
- 1/88 . Mounting, supporting, spacing, or insulating of electrodes or of electrode assemblies
- 1/90 . . Insulation between electrodes or supports within the vacuum space
- 1/92 . . Mountings for the electrode assembly as a whole
- 1/94 . . Mountings for individual electrodes
- 1/96 . . Spacing members extending to the envelope
- 1/98 . . . without fixed connection between spacing member and envelope
- 3/00 Details of electron-optical or ion-optical arrangements or of ion traps common to two or more basic types of discharge tubes or lamps**
- 3/02 . Electron guns [{\(electron guns for discharge tubes with provision for introducing objects or material to be exposed to the discharge H01J 37/06; for cathode ray tubes H01J 29/48\)}](#)
- 3/021 . . {Electron guns using a field emission, photo emission, or secondary emission electron source}
- 3/022 . . . {with microengineered cathode, e.g. Spindt-type}
- 3/023 . . {Electron guns using electron multiplication}
- 3/024 . . {Electron guns using thermionic emission of cathode heated by electron or ion bombardment or by irradiation by other energetic beams, e.g. by laser}
- 3/025 . . {Electron guns using a discharge in a gas or a vapour as electron source [\(gas-filled discharge tubes with gaseous cathodes H01J 15/00\)](#)}
- 3/026 . . {Eliminating deleterious effects due to thermal effects, electric or magnetic field [\(H01J 3/021 - H01J 3/025 take precedence\)](#)}
- 3/027 . . {Construction of the gun or parts thereof [\(H01J 3/021 - H01J 3/025, H01J 3/026 and H01J 3/028 take precedence\)](#)}
- 3/028 . . {Replacing parts of the gun; Relative adjustment [\(H01J 3/021 - H01J 3/025 take precedence\)](#)}
- 3/029 . . {Schematic arrangements for beam forming}
- 3/04 . Ion guns [{\(see provisionally also H01J 27/00\)}](#)
- 3/06 . two or more guns being arranged in a single vacuum space, e.g. for plural-ray tubes [\(H01J 3/07 takes precedence {see provisionally also H01J 29/46 - H01J 29/84}\)](#)
- 3/07 . Arrangements for controlling convergence of a plurality of beams [{\(see provisionally also H01J 29/46 - H01J 29/84\)}](#)
- 3/08 . Arrangements for controlling intensity of ray or beam [\(H01J 3/02, H01J 3/04 take precedence {see provisionally also H01J 29/46 - H01J 29/84}\)](#)
- 3/10 . Arrangements for centering ray or beam [\(H01J 3/02, H01J 3/04 take precedence {see provisionally also H01J 29/46 - H01J 29/84}\)](#)
- 3/12 . Arrangements for controlling cross-section of ray or beam; Arrangements for correcting aberration of beam, e.g. due to lenses [\(H01J 3/02, H01J 3/04 take precedence {see provisionally also H01J 29/46 - H01J 29/84}\)](#)

- 3/14 . Arrangements for focusing or reflecting ray or beam ([H01J 3/02](#), [H01J 3/04](#) take precedence {see provisionally also [H01J 29/46 - H01J 29/84](#)})
- 3/16 . . Mirrors {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/18 . . Electrostatic lenses {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/20 . . Magnetic lenses {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/22 . . . using electromagnetic means only {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/24 . . . using permanent magnets only {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/26 . Arrangements for deflecting ray or beam {([H01J 29/46 - H01J 29/84](#) and [H01J 37/147](#) take precedence)}
- 3/28 . . along one straight line or along two perpendicular straight lines {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/30 . . . by electric fields only {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/32 . . . by magnetic fields only {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/34 . . along a circle, spiral, or rotating radial line {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/36 . Arrangements for controlling the ray or beam after passing the main deflection system, e.g. for post-acceleration or post-concentration {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/38 . Mounting, supporting, spacing, or insulating electron-optical or ion-optical arrangements {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 3/381 . . {Dispersed generators}
- 3/383 . . . {the generators exploiting regenerative energy}
- 3/385 {Solar energy (generation of electric power by conversion of light [H02S](#))}
- 3/386 {Wind energy (wind motors [F03D](#))}
- 3/388 . . . {using fuel cells (fuel cells per se [H01M 8/00](#))}
- 3/40 . Traps for removing or diverting unwanted particles, e.g. negative ions, fringing electrons; Arrangements for velocity or mass selection {(see provisionally also [H01J 29/46 - H01J 29/84](#))}
- 5/00 Details relating to vessels or to leading-in conductors common to two or more basic types of discharge tubes or lamps**
- 5/02 . Vessels; Containers; Shields associated therewith; Vacuum locks
- 5/03 . . Arrangements for preventing or mitigating effects of implosion of vessels or containers
- 5/04 . . Vessels or containers characterised by the material thereof
- 5/06 . . Vessels or containers specially adapted for operation at high tension, e.g. by improved potential distribution over surface of vessel
- 5/08 . . provided with coatings on the walls thereof; Selection of materials for the coatings ([luminescent coatings H01J 1/62](#))
- 5/10 . . . on internal surfaces
- 5/12 . . Double-wall vessels or containers
- 5/125 . . . {with a gas tight space between both walls}
- 5/14 . . Dismountable vessels or containers, e.g. for replacing cathode heater
- 5/16 . . Optical or photographic arrangements structurally combined with the vessel
- 5/18 . . Windows permeable to X-rays, gamma-rays, or particles
- 5/20 . Seals between parts of vessels
- 5/22 . . Vacuum-tight joints between parts of vessel
- 5/24 . . . between insulating parts of vessel
- 5/26 . . . between insulating and conductive parts of vessel
- 5/28 . . . between conductive parts of vessel
- 5/30 . . . using packing-material, e.g. sealing-liquid or elastic insert
- 5/32 . Seals for leading-in conductors
- 5/34 . . for an individual conductor ([pinched-stem seals H01J 5/38](#); [end-disc seals H01J 5/40](#); [annular seals H01J 5/44](#))
- 5/36 . . . using intermediate part
- 5/38 . . Pinched-stem or analogous seals
- 5/40 . . End-disc seals, e.g. flat header
- 5/42 . . . using intermediate part
- 5/44 . . Annular seals disposed between the ends of the vessel
- 5/46 . Leading-in conductors
- 5/48 . Means forming part of the tube or lamp for the purpose of supporting it
- 5/50 . Means forming part of the tube or lamps for the purpose of providing electrical connection to it
- 5/52 . . directly applied to or forming part of the vessel
- 5/54 . . supported by a separate part, e.g. base
- 5/56 . . . Shape of the separate part
- 5/565 {Bases for circular lamps}
- 5/58 . . . Means for fastening the separate part to the vessel, e.g. by cement
- 5/60 for fastening by mechanical means
- 5/62 . . . Connection of wires protruding from the vessel to connectors carried by the separate part
- 7/00 Details not provided for in the preceding groups and common to two or more basic types of discharge tubes or lamps**
- 7/02 . Selection of substances for gas fillings; Specified operating pressure or temperature
- 7/04 . . having one or more carbon compounds as the principal constituent
- 7/06 . . having helium, argon, neon, krypton, or xenon as the principal constituent
- 7/08 . . having a metallic vapour as the principal constituent
- 7/10 . . . mercury vapour
- 7/12 . . . vapour of an alkali metal
- 7/14 . Means for obtaining or maintaining the desired pressure within the vessel
- 7/16 . . Means for permitting pumping during operation of the tube or lamp
- 7/18 . . Means for absorbing or adsorbing gas, e.g. by gettering
- 7/183 . . . {Composition or manufacture of getters}
- 7/186 . . . {Getter supports}
- 7/20 . . Means for producing, introducing, or replenishing gas or vapour during operation of the tube or lamp
- 7/22 . . Tubulations therefor, e.g. for exhausting; Closures therefor
- 7/24 . Cooling arrangements; Heating arrangements; Means for circulating gas or vapour within the discharge space

- 7/26 . . by flow of fluid through passages associated with tube or lamp
- 7/28 . . by latent heat or evaporation of cooling liquid
- 7/30 . Igniting arrangements
- 7/32 . . having resistive or capacitive igniter
- 7/34 . . . having resistive igniter only
- 7/36 . . Igniting by movement of a solid electrode
- 7/38 . . Igniting by movement of vessel as a whole, e.g. tilting
- 7/40 . . Igniting by associated radioactive materials or fillings
- 7/42 . Means structurally associated with the tube or lamp for indicating defects or previous use
- 7/44 . One or more circuit elements structurally associated with the tube or lamp
- 7/46 . . Structurally associated resonator having distributed inductance and capacitance
- 9/00 Apparatus or processes specially adapted for the manufacture {, installation, removal, maintenance} of electric discharge tubes, discharge lamps, or parts thereof; Recovery of material from discharge tubes or lamps**
- 9/003 . {Auxiliary devices for installing or removing discharge tubes or lamps}
- 9/006 . . {for fluorescent lamps}
- 9/02 . Manufacture of electrodes or electrode systems
- 9/022 . . {of cold cathodes}
- 9/025 . . . {of field emission cathodes}
- 9/027 . . . {of thin film cathodes}
- 9/04 . . of thermionic cathodes
- 9/042 . . . {Manufacture, activation of the emissive part}
- 9/045 {Activation of assembled cathode (regeneration [H01J 9/505](#))}
- 9/047 {Cathodes having impregnated bodies ([H01J 9/045](#) takes precedence)}
- 9/06 . . . Machines therefor
- 9/08 . . Manufacture of heaters for indirectly-heated cathodes
- 9/10 . . . Machines therefor
- 9/12 . . of photo-emissive cathodes; of secondary-emission electrodes
- 9/125 . . . {of secondary emission electrodes}
- 9/14 . . of non-emitting electrodes
- 9/142 . . . {of shadow-masks for colour television tubes}
- 9/144 {Mask treatment related to the process of dot deposition during manufacture of luminescent screen}
- 9/146 {Surface treatment, e.g. blackening, coating ([H01J 9/144](#) takes precedence)}
- 9/148 . . . {of electron emission flat panels, e.g. gate electrodes, focusing electrodes or anode electrodes}
- 9/16 . . . Machines for making wire grids
- 9/18 . . Assembling together the component parts of electrode systems
- 9/185 . . . {of flat panel display devices, e.g. by using spacers}
- 9/20 . Manufacture of screens on or from which an image or pattern is formed, picked up, converted or stored; Applying coatings to the vessel
- 9/205 . . {Applying optical coatings or shielding coatings to the vessel of flat panel displays, e.g. applying filter layers, electromagnetic interference shielding layers, anti-reflection coatings or anti-glare coatings}
- 9/22 . . Applying luminescent coatings
- 9/221 . . . {in continuous layers}
- 9/222 {constituted by coated granules emitting light of different colour}
- 9/223 {by uniformly dispersing of liquid}
- 9/224 {by precipitation}
- 9/225 {by electrostatic or electrophoretic processes}
- 9/227 . . . with luminescent material discontinuously arranged, e.g. in dots or lines
- 9/2271 {by photographic processes (final treatment of shadow-mask prior to or after dot deposition [H01J 9/144](#))}
- 9/2272 {Devices for carrying out the processes, e.g. light houses}
- 9/2273 {Auxiliary lenses and filters}
- 9/2274 {Light sources particularly adapted therefor}
- 9/2275 {including the exposition of a substance responsive to a particular radiation}
- 9/2276 {Development of latent electrostatic images ([per se G03G 15/06](#))}
- 9/2277 {by other processes, e.g. serigraphy, decalcomania}
- 9/2278 {Application of light absorbing material, e.g. between the luminescent areas}
- 9/233 . . Manufacture of photoelectric screens or charge-storage screens
- 9/236 . Manufacture of magnetic deflecting devices for cathode-ray tubes
- 9/24 . Manufacture or joining of vessels, leading-in conductors or bases
- 9/241 . . {the vessel being for a flat panel display ([H01J 9/261](#) takes precedence; flat discharge lamps [H01J 9/248](#))}
- 9/242 . . . {Spacers between faceplate and backplate}
- 9/244 . . {specially adapted for cathode ray tubes ([H01J 9/241](#), [H01J 9/26](#) take precedence)}
- 9/245 . . {specially adapted for gas discharge tubes or lamps ([H01J 9/241](#), [H01J 9/26](#) take precedence)}
- 9/247 . . . {specially adapted for gas-discharge lamps}
- 9/248 {the vessel being flat}
- 9/26 . . Sealing together parts of vessels
- 9/261 . . . {the vessel being for a flat panel display (for flat discharge lamps [H01J 9/268](#))}
- 9/263 . . . {specially adapted for cathode-ray tubes ([H01J 9/261](#) takes precedence)}
- 9/265 . . . {specially adapted for gas-discharge tubes or lamps ([H01J 9/261](#) takes precedence)}
- 9/266 {specially adapted for gas-discharge lamps}
- 9/268 {the vessel being flat}
- 9/28 . . Manufacture of leading-in conductors
- 9/30 . . Manufacture of bases
- 9/32 . . Sealing leading-in conductors
- 9/323 . . . {Sealing leading-in conductors into a discharge lamp or a gas-filled discharge device (for incandescent lamps [H01K 3/20](#), joining glass to metal [C03C 27/00](#))}
- 9/326 {making pinched-stem or analogous seals}

- 9/34 . . . Joining base to vessel
 - 9/36 . . . Joining connectors to internal electrode system
 - 9/38 . . . Exhausting, degassing, filling, or cleaning vessels
 - 9/385 . . . Exhausting vessels
 - 9/39 . . . Degassing vessels
 - 9/395 . . . Filling vessels
 - 9/40 . . . Closing vessels
 - 9/42 . . . Measurement or testing during manufacture
 - 9/44 . . . Factory adjustment of completed discharge tubes or lamps to comply with desired tolerances
 - 9/445 . . . {Aging of tubes or lamps, e.g. by "spot knocking" (cathode activation [H01J 9/045](#))}
 - 9/46 . . . Machines having sequentially arranged operating stations
 - 9/48 . . . with automatic transfer of workpieces between operating stations
 - 9/50 . . . Repairing or regenerating used or defective discharge tubes or lamps
 - 9/505 . . . {Regeneration of cathodes (activation [H01J 9/045](#))}
 - 9/52 . . . Recovery of material from discharge tubes or lamps ([H01J 9/50](#) takes precedence)
- 11/00 Gas-filled discharge tubes with alternating current induction of the discharge, e.g. AC-PDPs [Alternating Current Plasma Display Panels] (circuits or methods for driving PDPs [G09G 3/28](#)); Gas-filled discharge tubes without any main electrode inside the vessel; Gas-filled discharge tubes with at least one main electrode outside the vessel**
- NOTES**
1. When classifying in this group, classification is made in all appropriate places.
 2. In this group, the following term is used with the meaning indicated:
 - "main electrode" means any of a sustain electrode, scan electrode or address electrode.
- 11/10 . . . AC-PDPs with at least one main electrode being out of contact with the plasma
 - 11/12 . . . with main electrodes provided on both sides of the discharge space
 - 11/14 . . . with main electrodes provided only on one side of the discharge space
 - 11/16 . . . with main electrodes provided inside or on the side face of the spacers
 - 11/18 . . . containing a plurality of independent closed structures for containing the gas, e.g. plasma tube array [PTA] display panels
 - 11/20 . . . Constructional details
 - 11/22 . . . Electrodes, e.g. special shape, material or configuration
 - 11/24 Sustain electrodes or scan electrodes
 - 11/26 Address electrodes
 - 11/28 Auxiliary electrodes, e.g. priming electrodes or trigger electrodes
 - 11/30 Floating electrodes
 - 11/32 Disposition of the electrodes
 - 11/34 . . . Vessels, containers or parts thereof, e.g. substrates
 - 11/36 Spacers, barriers, ribs, partitions or the like
 - 11/38 Dielectric or insulating layers
 - 11/40 Layers for protecting or enhancing the electron emission, e.g. MgO layers
 - 11/42 Fluorescent layers
 - 11/44 Optical arrangements or shielding arrangements, e.g. filters, black matrices, light reflecting means or electromagnetic shielding means
 - 11/46 Connecting or feeding means, e.g. leading-in conductors
 - 11/48 Sealing, e.g. seals specially adapted for leading-in conductors
 - 11/50 Filling, e.g. selection of gas mixture
 - 11/52 Means for absorbing or adsorbing the gas mixture, e.g. by gettering
 - 11/54 Means for exhausting the gas
- 13/00 Discharge tubes with liquid-pool cathodes, e.g. metal-vapour rectifying tubes**
- 13/02 . . . Details
 - 13/04 . . . Main electrodes; Auxiliary anodes
 - 13/06 Cathodes
 - 13/08 characterised by the material
 - 13/10 Containers for the liquid pool; Arrangements or mounting thereof
 - 13/12 Positioning or moving the cathode spot on the surface of the pool
 - 13/14 Cooling, heating, circulating, filtering, or controlling level of the liquid
 - 13/16 Anodes; Auxiliary anodes for maintaining the discharge
 - 13/18 Cooling or heating of anodes
 - 13/20 Control electrodes, e.g. grid ([for igniting arrangements H01J 13/34](#))
 - 13/22 Screens, e.g. for preventing or eliminating arcing-back
 - 13/24 Vessels; Containers
 - 13/242 {characterised by the material}
 - 13/244 {characterised by the shape}
 - 13/246 {Treatment of, or coating on interior parts of vessel}
 - 13/248 {Envelope means outside vessel, i.e. screens, reflectors, filters}
 - 13/26 Seals between parts of vessels; Seals for leading-in conductors; Leading-in conductors
 - 13/263 {Leading-in conductors to the liquid electrode}
 - 13/266 {Leading-in conductors to the anode}
 - 13/28 Selection of substances for gas filling; Means for obtaining the desired pressure within the tube
 - 13/30 Means for permitting pumping during operation of the tube
 - 13/32 Cooling arrangements; Heating arrangements ([for cathodes H01J 13/14](#); [for anodes H01J 13/18](#))
 - 13/34 Igniting arrangements
 - 13/36 having resistive or capacitive igniter
 - 13/38 having resistive igniter only
 - 13/40 Igniting by movement of a solid electrode
 - 13/405 {Interrupting contact with liquid cathode}
 - 13/42 Igniting by movement of vessel as a whole, e.g. tilting
 - 13/44 Devices for preventing or eliminating arcing-back
 - 13/46 One or more circuit elements structurally associated with the tube

- 13/48 . . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 13/50 . Tubes having a single main anode
- 13/52 . . . with control by one or more intermediate control electrodes
- 13/54 . . . with control by igniter, e.g. single-anode ignitron
- 13/56 . Tubes having two or more main anodes
- 13/58 . . . with control by one or more intermediate control electrodes
- 15/00 Gas-filled discharge tubes with gaseous cathodes, e.g. plasma cathode**
- 15/02 . Details, e.g. electrode, gas filling, shape of vessel
- 15/04 . . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 17/00 Gas-filled discharge tubes with solid cathode**
([H01J 25/00](#), [H01J 27/00](#), [H01J 31/00](#) - [H01J 41/00](#) {, [H01J 11/00](#)} take precedence; gas filled spark gaps [H01T](#); Marx converters [H02M 7/26](#))
- 17/005 . {specially adapted as noise generators (electronic circuits for generation of noise currents or voltages [H03B 29/00](#))}
- 17/02 . Details
- 17/04 . . Electrodes; Screens
- 17/06 . . . Cathodes
- 17/063 {Indirectly heated cathodes, e.g. by the discharge itself}
- 17/066 {Cold cathodes}
- 17/08 having mercury or liquid alkali metal deposited on the cathode surface during operation of the tube
- 17/10 . . . Anodes
- 17/12 . . . Control electrodes
- 17/14 . . Magnetic means for controlling the discharge
- 17/16 . . Vessels; Containers
- 17/18 . . Seals between parts of vessels; Seals for leading-in conductors; Leading-in conductors
- 17/183 . . . {Seals between parts of vessel}
- 17/186 . . . {Seals between leading-in conductors and vessel}
- 17/20 . . Selection of substances for gas fillings; Specified operating pressures or temperatures
- 17/22 . . Means for obtaining or maintaining the desired pressure within the tube
- 17/24 . . . Means for absorbing or adsorbing gas, e.g. by gettering
- 17/26 . . . Means for producing, introducing, or replenishing gas or vapour during operation of the tube
- 17/28 . . Cooling arrangements
- 17/30 . . Igniting arrangements
- 17/32 . . . Igniting by associated radioactive materials or fillings
- 17/325 {Current stabilising tubes, e.g. curpistors}
- 17/34 . . One or more circuit elements structurally associated with the tube
- 17/36 . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 17/38 . Cold-cathode tubes
- 17/40 . . . with one cathode and one anode, e.g. glow tubes, tuning-indicator glow tubes, voltage-stabiliser tubes, voltage-indicator tubes, ([cathode-glow lamps H01J 61/04](#))
- 17/42 having one or more probe electrodes, e.g. for potential dividing
- 17/44 having one or more control electrodes
- 17/46 for preventing and then permitting ignition but thereafter having no control
- 17/48 . . . with more than one cathode or anode, e.g. sequence-discharge tube, counting tube, dekatron
- 17/485 {Plasma addressed liquid crystal displays [PALC]}
- 17/49 Display panels, e.g. with crossed electrodes {, e.g. making use of direct current ([display panels making use of alternating current H01J 11/00](#))}
- 17/491 {with electrodes arranged side by side and substantially in the same plane, e.g. for displaying alphanumeric characters}
- 17/492 {with crossed electrodes}
- 17/494 {using sequential transfer of the discharges, e.g. of the self-scan type ([addressing circuits therefor G09G 3/29](#))}
- 17/495 {display panels using sequential transfer of the discharge along dielectric storage elements}
- 17/497 {for several colours}
- 17/498 {with a gas discharge space and a post acceleration space for electrons}
- 17/50 . Thermionic-cathode tubes
- 17/52 . . . with one cathode and one anode
- 17/54 having one or more control electrodes
- 17/56 for preventing and then permitting ignition, but thereafter having no control
- 17/58 . . . with more than one cathode or anode
- 17/60 the discharge paths priming each other in a predetermined sequence, e.g. counting tube
- 17/62 with independent discharge paths controlled by intermediate electrodes, e.g. polyphase rectifier
- 17/64 . Tubes specially designed for switching or modulating in a waveguide, e.g. TR box
- 19/00 Details of vacuum tubes of the types covered by group [H01J 21/00](#)**
- 19/02 . Electron-emitting electrodes; Cathodes
- 19/04 . . Thermionic cathodes
- 19/06 . . . characterised by the material
- 19/062 with alkaline-earth metal oxides, or such oxides used in conjunction with reducing agents, as an emissive material
- 19/064 with other metal oxides as an emissive material
- 19/066 with metals or alloys as an emissive material
- 19/068 with compounds having metallic conductive properties, e.g. lanthanum boride, as an emissive material
- 19/08 . . . Cathodes heated directly by an electric current
- 19/10 . . . characterised by the shape
- 19/12 Supports; Vibration-damping arrangements
- 19/14 Cathodes heated indirectly by an electric current; Cathodes heated by electron or ion bombardment
- 19/16 Heaters

19/18 Insulating layer or body located between heater and emissive material	21/105 {with microengineered cathode and control electrodes, e.g. Spindt-type}
19/20 Supports for the emissive material	21/12 Tubes with variable amplification factor
19/22 Dispenser-type cathodes, e.g. L-cathode	21/14 Tubes with means for concentrating the electron stream, e.g. beam tetrode
19/24	. . Cold cathodes, e.g. field-emissive cathode	21/16	. . . with external electrostatic control means and with or without internal control electrodes
19/28	. Non-electron-emitting electrodes; Screens	21/18	. . having magnetic control means; having both magnetic and electrostatic control means
19/30	. . characterised by the material	21/20	. Tubes with more than one discharge path; Multiple tubes, e.g. double diode, triode-hexode
19/32	. . Anodes	21/22	. . with movable electrode or electrodes
19/34	. . . forming part of the envelope	21/24	. . with variable amplification factor
19/36	. . . Cooling of anodes	21/26	. . with means for concentrating the electron stream
19/38	. . Control electrodes, e.g. grid	21/34	. Tubes with electrode system arranged or dimensioned so as to eliminate transit-time effect (with flat electrodes H01J 21/36)
19/40	. . Screens for shielding	21/36	. Tubes with flat electrodes, e.g. disc electrode
19/42	. Mounting, supporting, spacing, or insulating of electrodes or of electrode assemblies	23/00	Details of transit-time tubes of the types covered by group H01J 25/00
19/44	. . Insulation between electrodes or supports within the vacuum space	23/005	. {Cooling methods or arrangements (H01J 23/033 takes precedence)}
19/46	. . Mountings for the electrode assembly as a whole	23/02	. Electrodes; Magnetic control means; Screens (associated with resonator or delay system H01J 23/16)
19/48	. . Mountings for individual electrodes	23/027	. . Collectors
19/50	. . Spacing members extending to the envelope	23/0275	. . . {Multistage collectors}
19/52	. . . without fixed connection between spacing member and envelope	23/033	. . . Collector cooling devices
19/54	. Vessels; Containers; Shields associated therewith	23/04	. . Cathodes
19/56	. . characterised by the material of the vessel or container	23/05	. . . having a cylindrical emissive surface, e.g. cathodes for magnetrons
19/57	. . provided with coatings on the walls thereof; Selection of materials for the coatings	23/06	. . Electron or ion guns
19/58	. Seals between parts of vessels	23/065	. . . producing a solid cylindrical beam (H01J 23/075 takes precedence)
19/60	. Seals for leading-in conductors	23/07	. . . producing a hollow cylindrical beam (H01J 23/075 takes precedence)
19/62	. Leading-in conductors	23/075	. . . Magnetron injection guns
19/64	. Means forming part of the tube for the purpose supporting it	23/08	. . Focusing arrangements, e.g. for concentrating stream of electrons, for preventing spreading of stream
19/66	. Means forming part of the tube for the purpose of providing electrical connection to it (H01J 5/46 - H01J 5/62 take precedence)	23/083	. . . Electrostatic focusing arrangements
19/68	. Specified gas introduced into the tube at low pressure, e.g. for reducing or influencing space charge	23/087	. . . Magnetic focusing arrangements
19/70	. Means for obtaining or maintaining the vacuum, e.g. by gettering	23/0873 {with at least one axial-field reversal along the interaction space, e.g. P.P.M. focusing}
19/72	. . Tubulations therefor, e.g. for exhausting; Closures therefor	23/0876 {with arrangements improving the linearity and homogeneity of the axial field, e.g. field straightener}
19/74	. Cooling arrangements (cooling of anodes H01J 19/36)	23/09	. . Electric systems for directing or deflecting the discharge along a desired path, e.g. E-type (focusing arrangements H01J 23/08)
19/76	. Means structurally associated with the tube for indicating defects or previous use	23/10	. . Magnet systems for directing or deflecting the discharge along a desired path, e.g. a spiral path (magnetic focusing arrangements H01J 23/08)
19/78	. One or more circuit elements structurally associated with the tube	23/11	. . Means for reducing noise (in electron or ion gun H01J 23/06)
19/80	. . Structurally associated resonator having distributed inductance and capacitance	23/12	. Vessels; Containers
19/82	. Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for	23/14	. Leading-in arrangements; Seals therefor
21/00	Vacuum tubes (H01J 25/00, H01J 31/00 - H01J 40/00, H01J 43/00, H01J 47/00, H01J 49/00 take precedence; details of vacuum tubes H01J 19/00)	23/15	. . Means for preventing wave energy leakage structurally associated with tube leading-in arrangements, e.g. filters, chokes, attenuating devices
21/02	. Tubes with a single discharge path		
21/04	. . without control means, i.e. diodes		
21/06	. . having electrostatic control means only		
21/065	. . . {Devices for short wave tubes}		
21/08	. . . with movable electrode or electrodes		
21/10	. . . with one or more immovable internal control electrodes, e.g. triode, pentode, octode		

- 23/16 . . . Circuit elements, having distributed capacitance and inductance, structurally associated with the tube and interacting with the discharge
- 23/165 . . . {[Manufacturing processes or apparatus therefore](#)}
- 23/18 . . . Resonators
- 23/20 . . . Cavity resonators; Adjustment or tuning thereof
- 23/207 Tuning of single resonator
- 23/213 Simultaneous tuning of more than one resonator, e.g. resonant cavities of a magnetron
- 23/22 . . . Connections between resonators, e.g. strapping for connecting resonators of a magnetron
- 23/24 . . . Slow-wave structures {, e.g. [delay systems](#)}
- 23/26 . . . Helical slow-wave structures; Adjustment therefor
- 23/27 Helix-derived slow-wave structures
- 23/28 . . . Interdigital slow-wave structures; Adjustment therefor
- 23/30 . . . Damping arrangements associated with slow-wave structures, e.g. for suppression of unwanted oscillations
- 23/34 . . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 23/36 . . . Coupling devices having distributed capacitance and inductance, structurally associated with the tube, for introducing or removing wave energy
- 23/38 . . . to or from the discharge
- 23/40 . . . to or from the interaction circuit
- 23/42 . . . the interaction circuit being a helix or a helix-derived slow-wave structure ([H01J 23/44 - H01J 23/48 take precedence](#))
- 23/44 . . . Rod-type coupling devices ([H01J 23/46](#), [H01J 23/48](#), [H01J 23/54 take precedence](#))
- 23/46 . . . Loop coupling devices
- 23/48 . . . for linking interaction circuit with coaxial lines; Devices of the coupled helices type ([H01J 23/46 takes precedence](#))
- 23/50 the interaction circuit being a helix or derived from a helix ([H01J 23/52 takes precedence](#))
- 23/52 the coupled helices being disposed coaxially around one another
- 23/54 . . . Filtering devices preventing unwanted frequencies or modes to be coupled to, or out of, the interaction circuit; Prevention of high frequency leakage in the environment
- 25/00** **Transit-time tubes, e.g. klystrons, travelling-wave tubes, magnetrons** ([details of transit-time tubes H01J 23/00](#); [particle accelerators H05H](#))
- 25/005 . . . {[Gas-filled transit-time tubes](#)}
- 25/02 . . . Tubes with electron stream modulated in velocity or density in a modulator zone and thereafter giving up energy in an inducing zone, the zones being associated with one or more resonators
- 25/025 . . . {[with an electron stream following a helical path](#)}
- 25/04 . . . Tubes having one or more resonators, without reflection of the electron stream, and in which the modulation produced in the modulator zone is mainly density modulation, e.g. Heaff tube
- 25/06 . . . Tubes having only one resonator, without reflection of the electron stream, and in which the modulation produced in the modulator zone is mainly velocity modulation, e.g. Lüdi-Klystron
- 25/08 . . . with electron stream perpendicular to the axis of the resonator
- 25/10 . . . Klystrons, i.e. tubes having two or more resonators, without reflection of the electron stream, and in which the stream is modulated mainly by velocity in the zone of the input resonator
- 25/11 Extended interaction klystrons
- 25/12 . . . with pencil-like electron stream in the axis of the resonators
- 25/14 . . . with tube-like electron stream coaxial with the axis of the resonators
- 25/16 . . . with pencil-like electron stream perpendicular to the axis of the resonators
- 25/18 . . . with radial or disc-like electron stream perpendicular to the axis of the resonators
- 25/20 . . . having special arrangements in the space between resonators, e.g. resistive-wall amplifier tube, space-charge amplifier tube, velocity-jump tube
- 25/22 . . . Reflex klystrons, i.e. tubes having one or more resonators, with a single reflection of the electron stream, and in which the stream is modulated mainly by velocity in the modulator zone
- 25/24 . . . in which the electron stream is in the axis of the resonator or resonators and is pencil-like before reflection
- 25/26 . . . in which the electron stream is coaxial with the axis of the resonator or resonators and is tube-like before reflection
- 25/28 . . . in which the electron stream is perpendicular to the axis of the resonator or resonators and is pencil-like before reflection
- 25/30 . . . in which the electron stream is perpendicular to the axis of the resonator or resonators and is radial or disc-like before reflection
- 25/32 . . . Tubes with plural reflection, e.g. Coeterier tube
- 25/34 . . . Travelling-wave tubes; Tubes in which a travelling wave is simulated at spaced gaps
- 25/36 . . . Tubes in which an electron stream interacts with a wave travelling along a delay line or equivalent sequence of impedance elements, and without magnet system producing an H-field crossing the E-field
- 25/38 . . . the forward travelling wave being utilised
- 25/40 . . . the backward travelling wave being utilised
- 25/42 . . . Tubes in which an electron stream interacts with a wave travelling along a delay line or equivalent sequence of impedance elements, and with a magnet system producing an H-field crossing the E-field ([with travelling wave moving completely around the electron space H01J 25/50](#))
- 25/44 . . . the forward travelling wave being utilised
- 25/46 . . . the backward travelling wave being utilised
- 25/48 . . . Tubes in which two electron streams of different velocities interact with one another, e.g. electron-wave tube
- 25/49 . . . Tubes using the parametric principle, e.g. for parametric amplification
- 25/50 . . . Magnetrons, i.e. tubes with a magnet system producing an H-field crossing the E-field ([with travelling wave not moving completely around the electron space H01J 25/42](#); [functioning with plural reflection or with reversed cyclotron action H01J 25/62](#), [H01J 25/64](#))

- 25/52 . . with an electron space having a shape that does not prevent any electron from moving completely around the cathode or guide electrode
- 25/54 . . . having only one cavity or other resonator, e.g. neutrode tubes
- 25/55 Coaxial cavity magnetrons
- 25/56 with interdigital arrangements of anodes, e.g. turbator tube
- 25/58 . . . having a number of resonators; having a composite resonator, e.g. a helix
- 25/587 Multi-cavity magnetrons
- 25/593 Rising-sun magnetrons
- 25/60 . . with an electron space having a shape that prevents any electron from moving completely around the cathode or guide electrode; Linear magnetrons
- 25/61 . Hybrid tubes, i.e. tubes comprising a klystron section and a travelling-wave section
- 25/62 . Strophotrons, i.e. tubes with H-field crossing the E-field and functioning with plural reflection
- 25/64 . Turbine tubes, i.e. tubes with H-field crossing the E-field and functioning with reversed cyclotron action
- 25/66 . Tubes with electron stream crossing itself and thereby interacting or interfering with itself
- 25/68 . Tubes specially designed to act as oscillator with positive grid and retarding field, e.g. for Barkhausen-Kurz oscillators (with secondary emission [H01J 25/76](#))
- 25/70 . . with resonator having distributed inductance with capacitance, e.g. Pintsch tube
- 25/72 . . in which a standing wave or a considerable part thereof is produced along an electrode, e.g. Clavier tube (with resonator having distributed inductance and capacitance [H01J 25/70](#))
- 25/74 . Tubes specially designed to act as transit-time diode oscillators, e.g. monotrons
- 25/76 . Dynamic electron-multiplier tubes, e.g. Farnsworth multiplier tube, multipactor
- 25/78 . Tubes with electron stream modulated by deflection in a resonator
- 27/00 Ion beam tubes ([H01J 25/00](#), [H01J 33/00](#), [H01J 37/00](#) take precedence; particle accelerators [H05H](#))**
- 27/02 . Ion sources; Ion guns {(for examination or processing discharge tubes [H01J 37/08](#); ion sources, ion guns for particle spectrometer or separator tubes [H01J 49/10](#); ion propulsion [F03H 1/00](#))}
- 27/022 . . {Details}
- 27/024 . . . {Extraction optics, e.g. grids}
- 27/026 . . {Cluster ion sources}
- 27/028 . . {Negative ion sources}
- 27/04 . . using reflex discharge, e.g. Penning ion sources {(electron bombardment ion sources [H01J 27/08](#))}
- 27/06 . . . without applied magnetic field
- 27/08 . . using arc discharge
- 27/10 . . . Duoplasmatrons {; Duopigatrons}
- 27/12 provided with an expansion cup
- 27/14 . . . Other arc discharge ion sources using an applied magnetic field
- 27/143 {Hall-effect ion sources with closed electron drift}
- 27/146 {End-Hall type ion sources, wherein the magnetic field confines the electrons in a central cylinder}
- 27/16 . . using high-frequency excitation, e.g. microwave excitation
- 27/18 . . . with an applied axial magnetic field
- 27/20 . . using particle {beam} bombardment, e.g. ionisers
- 27/205 . . . {with electrons, e.g. electron impact ionisation, electron attachment}
- 27/22 . . . Metal ion sources
- 27/24 . . using photo-ionisation, e.g. using laser beam
- 27/26 . . using surface ionisation, e.g. field effect ion sources, thermionic ion sources ([H01J 27/20](#), [H01J 27/24](#) take precedence)
- 29/00 Details of cathode-ray tubes or of electron-beam tubes of the types covered by group [H01J 31/00](#)**
- 29/003 . {Arrangements for eliminating unwanted electromagnetic effects, e.g. demagnetisation arrangements, shielding coils ([H01J 29/06](#), [H01J 29/867](#) take precedence; demagnetisation in general [H01F 13/00](#); circuit arrangements therefor [H04N 9/29](#); screening of apparatus against electric or magnetic fields [H05K 9/00](#))}
- 29/006 . {Arrangements for eliminating unwanted temperature effects}
- 29/02 . Electrodes; Screens; Mounting, supporting, spacing or insulating thereof
- 29/021 . . {arrangements for eliminating interferences in the tube ([H01J 29/484](#) takes precedence)}
- 29/023 . . {secondary-electron emitting electrode arrangements (secondary-emission tubes [H01J 43/00](#))}
- 29/025 . . {Mounting or supporting arrangements for grids ([H01J 29/028](#) takes precedence)}
- 29/026 . . {Mounting or supporting arrangements for charge storage screens not deposited on the frontplate}
- 29/028 . . {Mounting or supporting arrangements for flat panel cathode ray tubes, e.g. spacers particularly relating to electrodes}
- 29/04 . . Cathodes
- 29/06 . . Screens for shielding; Masks interposed in the electron stream
- 29/07 . . . Shadow masks for colour television tubes
- 29/073 {Mounting arrangements associated with shadow masks}
- 29/076 {characterised by the shape or distribution of beam-passing apertures}
- 29/08 . . Electrodes intimately associated with a screen on or from which an image or pattern is formed, picked-up, converted or stored, e.g. backing-plates for storage tubes or collecting secondary electrons
- 29/085 . . . {Anode plates, e.g. for screens of flat panel displays}
- 29/10 . . Screens on or from which an image or pattern is formed, picked up, converted or stored
- 29/12 . . . acting as light valves by shutter operation, e.g. for eidophor
- 29/14 . . . acting by discoloration, e.g. halide screen
- 29/16 . . . Incandescent screens
- 29/18 . . . Luminescent screens

- 29/182 { acting upon the lighting-up of the luminescent material other than by the composition of the luminescent material, e.g. by infra red or UV radiation, heating or electric fields }
- 29/185 { measures against halo-phenomena }
- 29/187 { screens with more than one luminescent material (as mixtures for the treatment of the screens) (for several superimposed luminescent layers [H01J 29/26](#); for adjacent dots or lines of different luminescent material [H01J 29/32](#)) }
- 29/20 characterised by the luminescent material { (for luminescent screens for X-ray purposes [G21K 4/00](#)) }
- 29/22 characterised by the binder or adhesive for securing the luminescent material to its support, e.g. vessel
- 29/225 { photosensitive adhesive }
- 29/24 Supports for luminescent material
- 29/26 with superimposed luminescent layers
- 29/28 with protective, conductive or reflective layers
- 29/30 with luminescent material discontinuously arranged, e.g. in dots, in lines
- 29/32 with adjacent dots or lines of different luminescent material, e.g. for colour television
- 29/322 { with adjacent dots }
- 29/325 { with adjacent lines }
- 29/327 { Black matrix materials }
- 29/34 provided with permanent marks or references
- 29/36 . . . Photoelectric screens; Charge-storage screens
- 29/38 not using charge storage, e.g. photo-emissive screen, extended cathode { (electrodes using photo-emission in general [H01J 1/34](#)) }
- 29/385 { Photocathodes comprising a layer which modified the wave length of impinging radiation (luminescent layers sensitive to UV and X-rays [C09K 11/00](#), [G21K 4/00](#)) }
- 29/39 Charge-storage screens { ([H01J 29/395](#) takes precedence) }
- 29/395 { charge-storage grids exhibiting triode effect }
- 29/41 using secondary emission, e.g. for supericonoscope { (electrodes using secondary emission in general [H01J 1/32](#); secondary emission tubes [H01J 43/00](#)) }
- 29/413 { for writing and reading of charge pattern on opposite sides of the target, e.g. for superorthicon }
- 29/416 { with a matrix of electrical conductors traversing the target }
- 29/43 using photo-emissive mosaic, e.g. for orthicon, for iconoscope
- 29/435 { with a matrix of conductors traversing the target }
- 29/44 exhibiting internal electric effects caused by particle radiation, e.g. bombardment-induced conductivity { (particle detectors exhibiting internal electric effects [G01T 1/26](#)) }
- 29/45 exhibiting internal electric effects caused by electromagnetic radiation, e.g. photoconductive screen, photodielectric screen, photovoltaic screen { (photoconductive layers for electrography [G03G 5/00](#)) }
- 29/451 { with photosensitive junctions }
- 29/453 { provided with diode arrays }
- 29/455 { formed on a silicon substrate }
- 29/456 { exhibiting no discontinuities, e.g. consisting of uniform layers }
- 29/458 { pyroelectrical targets; targets for infra-red or ultra-violet or X-ray radiations }
- 29/46 . . Arrangements of electrodes and associated parts for generating or controlling the ray or beam, e.g. electron-optical arrangement { (transit time tubes [H01J 23/00](#), [H01J 25/00](#); X-ray tubes [H01J 35/00](#); beam tubes for examining ions, e.g. electron or ion microscopes, or processing of objects or materials, e.g. electron or ion beam tubes [H01J 37/04](#); electron multipliers [H01J 43/04](#); handling of radiation or particles, e.g. focusing, deviating, not otherwise provided for [G21K 1/00](#)) }
- NOTE**
- [H01J 29/48](#) takes precedence over groups [H01J 29/52](#) - [H01J 29/58](#).
- 29/462 . . { arrangements for interrupting the beam during inoperative periods }
- 29/465 . . { for simultaneous focalisation and deflection of ray or beam }
- 29/467 . . { Control electrodes for flat display tubes, e.g. of the type covered by group [H01J 31/123](#) }
- 29/48 . . Electron guns
- 29/481 . . . { Electron guns using field-emission, photo-emission, or secondary-emission electron source }
- 29/482 . . . { Electron guns using electron multiplication }
- 29/484 . . . { Eliminating deleterious effects due to thermal effects, electrical or magnetic fields; Preventing unwanted emission ([H01J 29/481](#) and [H01J 29/482](#) take precedence) }
- 29/485 . . . { Construction of the gun or of parts thereof ([H01J 29/481](#), [H01J 29/482](#), [H01J 29/484](#) and [H01J 29/487](#) take precedence) }
- 29/487 . . . { Replacing parts of the gun; Relative adjustment of the electrodes ([H01J 29/481](#) and [H01J 29/482](#) take precedence; vacuum locks [H01J 29/865](#)) }
- 29/488 . . . { Schematic arrangements of the electrodes for beam forming; Place and form of the electrodes }
- 29/50 . . . two or more guns in a single vacuum space, e.g. for plural-ray tube ([H01J 29/51](#) takes precedence)
- 29/503 { Three or more guns, the axes of which lay in a common plane }
- 29/506 { guns in delta or circular configuration }
- 29/51 . . . Arrangements for controlling convergence of a plurality of beams { by means of electric field only }
- 29/52 . . Arrangements for controlling intensity of ray or beam, e.g. for modulation { ([H01J 29/467](#) takes precedence) }

- 29/525 . . . {Digitally controlled systems, e.g. Digisplay}
- 29/54 . . Arrangements for centring ray or beam
{(H01J 29/467 takes precedence)}
- 29/56 . . Arrangements for controlling cross-section of ray or beam; Arrangements for correcting aberration of beam, e.g. due to lenses {(H01J 29/467 takes precedence)}
- 29/563 . . . {for controlling cross-section}
- 29/566 . . . {for correcting aberration}
- 29/58 . . Arrangements for focusing or reflecting ray or beam {(H01J 29/467, H01J 29/585 take precedence)}
- 29/585 . . . {in which the transit time of the electrons has to be taken into account}
- 29/60 . . . Mirrors
- 29/62 . . . Electrostatic lenses
- 29/622 {producing fields exhibiting symmetry of revolution}
- 29/624 {co-operating with or closely associated to an electron gun}
- 29/626 {producing fields exhibiting periodic axial symmetry, e.g. multipolar fields}
- 29/628 {co-operating with or closely associated to an electron gun}
- 29/64 . . . Magnetic lenses
- 29/66 using electromagnetic means only
- 29/68 using permanent magnets only
- 29/70 . . Arrangements for deflecting ray or beam
{(H01J 29/467, H01J 29/525 take precedence)}
- 29/701 . . . {Systems for correcting deviation or convergence of a plurality of beams by means of magnetic fields at least}
- 29/702 {Convergence correction arrangements therefor}
- 29/703 {Static convergence systems}
- 29/705 {Dynamic convergence systems}
- 29/706 {Deviation correction devices, i.e. having the same action on each beam}
- 29/707 {Arrangements intimately associated with parts of the gun and co-operating with external magnetic excitation devices}
- 29/708 . . . {in which the transit time of the electrons has to be taken into account}
- 29/72 . . . along one straight line or along two perpendicular straight lines
- 29/74 Deflecting by electric fields only
- 29/76 Deflecting by magnetic fields only
- 29/762 {using saddle coils or printed windings (coils per se H01F)}
- 29/764 {using toroidal windings}
- 29/766 {using a combination of saddle coils and toroidal windings}
- 29/768 {using printed windings (printed windings in general H01F 27/2804; manufacturing printed coils per se H01F 41/04; printed circuits and apparatus or processes for manufacturing printed circuits in general H05K 1/00, e.g. H05K 1/16, and H05K 3/00)}
- 29/78 . . . along a circle, spiral or rotating radial line, e.g. for radar display
- 29/80 . . Arrangements for controlling the ray or beam after passing the main deflection system, e.g. for post-acceleration or post-concentration, for colour switching {(H01J 29/701 takes precedence)}
- 29/803 {for post-acceleration or post-deflection, e.g. for colour switching}
- 29/806 {Electron lens mosaics, e.g. fly's eye lenses, colour selection lenses}
- 29/81 using shadow masks
- 29/82 . . Mounting, supporting, spacing, or insulating electron-optical or ion-optical arrangements
- 29/823 {around the neck of the tube}
- 29/826 {Deflection arrangements}
- 29/84 . . Traps for removing or diverting unwanted particles, e.g. negative ions, fringing electrons; Arrangements for velocity or mass selection
- 29/845 . . . {by means of magnetic systems}
- 29/86 . . Vessels; Containers; Vacuum locks
- 29/861 . . . {Vessels or containers characterised by the form or the structure thereof}
- 29/862 {of flat panel cathode ray tubes}
- 29/863 . . . {Vessels or containers characterised by the material thereof}
- 29/864 . . . {Spacers between faceplate and backplate of flat panel cathode ray tubes}
- 29/865 . . . {Vacuum locks (for tubes for examining or processing of objects or materials, e.g. electron microscopes H01J 37/18)}
- 29/866 {Devices for introducing a recording support into the vessel}
- 29/867 . . . {Means associated with the outside of the vessel for shielding, e.g. magnetic shields (screens for shielding inside the vessel H01J 29/06; magnetic shielding in general H05K 9/00)}
- 29/868 {Screens covering the input or output face of the vessel, e.g. transparent anti-static coatings, X-ray absorbing layers}
- 29/87 . . Arrangements for preventing or limiting effects of implosion of vessels or containers
- 29/88 . . provided with coatings on the walls thereof; Selection of materials for the coatings
{(H01J 29/868 and H01J 29/89 take precedence)}
- 29/89 . . Optical or photographic arrangements structurally combined {or co-operating} with the vessel {(H01J 29/866 and H01J 29/868 take precedence)}
- 29/892 {using fibre optics}
- 29/894 {Arrangements combined with the vessel for the purpose of image projection on a screen (projection arrangements for image reproduction, e.g. using eidophor H04N 5/74)}
- 29/896 {Anti-reflection means, e.g. eliminating glare due to ambient light}
- 29/898 {Spectral filters}
- 29/90 . . Leading-in arrangements; Seals therefor
- 29/92 . . Means forming part of the tube for the purpose of providing electrical connection to it
- 29/925 . . . {High voltage anode feedthrough connectors for display tubes}
- 29/94 . . Selection of substances for gas fillings; Means for obtaining or maintaining the desired pressure within the tube, e.g. by gettering {(exhausting, degassing, gettering of electric discharge tubes in general H01J 9/38)}

- 29/96 . . . One or more circuit elements structurally associated with the tube
- 29/98 . . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 31/00 Cathode ray tubes; Electron beam tubes**
([H01J 25/00](#), [H01J 33/00](#), [H01J 35/00](#), [H01J 37/00](#) take precedence; details of cathode ray tubes or of electron beam tubes [H01J 29/00](#))
- 31/02 . . . having one or more output electrodes which may be impacted selectively by the ray or beam, and onto, from, or over which the ray or beam may be deflected or de-focused {(pulse counting circuits therewith [H03K 29/06](#))}
- 31/04 . . . with only one or two output electrodes {with only two electrically independent groups or electrodes}
- 31/06 . . . with more than two output electrodes, e.g. for multiple switching or counting
- 31/065 . . . {for electrography or electrophotography, for transferring a charge pattern through the faceplate (leading-in arrangements [H01J 29/90](#); Lenard tubes [H01J 33/00](#); electrography or electrophotography per se [G03C](#))}
- 31/08 . . . having a screen on or from which an image or pattern is formed, picked up, converted, or stored
- 31/10 . . . Image or pattern display tubes, i.e. having electrical input and optical output; Flying-spot tubes for scanning purposes
- 31/12 . . . with luminescent screen
- 31/121 {tubes for oscillography (colour display tubes [H01J 31/20](#); cathode ray oscillography [G01R 13/20](#))}
- 31/122 {Direct viewing storage tubes without storage grid (with storage grid [H01J 31/18](#))}
- 31/123 {Flat display tubes}
- 31/124 {using electron beam scanning}
- 31/125 {provided with control means permitting the electron beam to reach selected parts of the screen, e.g. digital selection}
- 31/126 {using line sources}
- 31/127 {using large area or array sources, i.e. essentially a source for each pixel group}
- 31/128 {provided with control means permitting the electron beam to reach selected parts of the screen, e.g. digitally controlled display tubes ([H01J 31/123](#) takes precedence)}
- 31/14 Magic-eye or analogous tuning indicators {(mounting of visual indicators in a radio set [H03J 1/04](#); circuits for timing indicators [H03J 3/14](#))}
- 31/15 with ray or beam selectively directed to luminescent anode segments {(printing by application of radiation [B41J 2/447](#))}
- 31/16 with mask carrying a number of selectively displayable signs, e.g. charactron, numeroscope {(tubes with a mask carrying a matrix of openings, a selection of which permits a sign to be displayed [H01J 31/128](#))}
- 31/18 with image written by a ray or beam on a grid-like charge-accumulating screen, and with a ray or beam passing through and influenced by this screen before striking the luminescent screen, e.g. direct-view storage tube {(charge storage grids exhibiting triode effect [H01J 29/395](#))}
- 31/20 for displaying images or patterns in two or more colours {(circuits for colour television [H04N 9/16](#) - [H04N 9/28](#))}
- 31/201 {using a colour-selection electrode}
- 31/203 {with more than one electron beam}
- 31/205 {with three electron beams in delta configuration}
- 31/206 {with three coplanar electron beams}
- 31/208 {using variable penetration depth of the electron beam in the luminescent layer, e.g. penitrons}
- 31/22 for stereoscopic displays
- 31/24 with screen acting as light valve by shutter operation, e.g. eidophor {(projection arrangements for image reproduction, e.g. using eidophor [H04N 5/74](#))}
- 31/26 . . . Image pick-up tubes having an input of visible light and electric output (tubes without defined electron beams and having a light ray scanning photo-emissive screen [H01J 40/20](#))
- 31/265 {with light spot scanning}
- 31/28 with electron ray scanning the image screen {([H01J 31/283](#), [H01J 31/286](#) take precedence)}
- 31/283 {with a target comprising semiconductor junctions}
- 31/286 {correlater tubes}
- 31/30 having regulation of screen potential at anode potential, e.g. iconoscope
- 31/32 Tubes with image amplification section, e.g. image-iconoscope, supericonoscope
- 31/34 having regulation of screen potential at cathode potential, e.g. orthicon
- 31/36 Tubes with image amplification section, e.g. image-orthicon
- 31/38 Tubes with photoconductive screen, e.g. vidicon
- 31/40 having grid-like image screen through which the electron ray passes and by which the ray is influenced before striking the output electrode, i.e. having "triode action"
- 31/42 with image screen generating a composite electron beam which is deflected as a whole past a stationary probe to simulate a scanning effect, e.g. Farnsworth pick-up tube
- 31/44 Tubes with image amplification section
- 31/46 Tubes in which electrical output represents both intensity and colour of image {(colour television cameras with only one tube [H04N 9/07](#))}
- 31/48 Tubes with amplification of output effected by electron multiplier arrangements within the vacuum space
- 31/49 Pick-up adapted for an input of electromagnetic radiation other than visible light and having an electric output, e.g. for an input of X-rays, for an input of infra-red radiation

- 31/495 . . . Pick-up tubes adapted for an input of sonic, ultrasonic, or mechanical vibrations and having an electric output
- 31/50 . . . Image-conversion or image-amplification tubes, i.e. having optical, X-ray, or analogous input, and optical output
- 31/501 . . . {with an electrostatic electron optic system ([H01J 31/52](#) - [H01J 31/56](#) take precedence)}
- 31/502 {with means to interrupt the beam, e.g. shutter for high speed photography (circuits using electron-beam shutters [G03B 27/725](#))}
- 31/503 . . . {with an electromagnetic electron-optic system ([H01J 31/52](#) - [H01J 31/56](#) take precedence)}
- 31/505 . . . {flat tubes, e.g. proximity focusing tubes}
- 31/506 . . . {tubes using secondary emission effect}
- 31/507 {using a large number of channels, e.g. microchannel plates}
- 31/508 . . . {Multistage converters}
- 31/52 . . . having grid-like image screen through which the electron ray or beam passes and by which the ray or beam is influenced before striking the luminescent output screen, i.e. having "triode action"
- 31/54 . . . in which the electron ray or beam is reflected by the image input screen on to the image output screen
- 31/56 . . . for converting or amplifying images in two or more colours
- 31/58 . . . Tubes for storage of image or information pattern or for conversion of definition of television or like images, i.e. having electrical input and electrical output ({[electrostatic memories using electron beam tubes G11C 11/23](#)})
- 31/585 . . . {Monoscopes ([H01J 31/60](#) takes precedence)}
- 31/60 . . . having means for deflecting, either selectively or sequentially, an electron ray on to separate surface elements of the screen ([by circuitry alone H01J 29/08](#))
- 31/62 with separate reading and writing rays
- 31/64 on opposite sides of screen, e.g. for conversion of definition
- 31/66 . . . having means for allowing all but selected cross-section elements of a homogeneous electron beam to reach corresponding elements of the screen, e.g. selectron
- 31/68 . . . in which the information pattern represents two or more colours
- 33/00 Discharge tubes with provision for emergence of electrons or ions from the vessel ({[irradiation devices G21K](#)}; [particle accelerators H05H](#)); **Lenard tubes****
- 33/02 . . . Details ({[vessels for operation at high tension H01J 5/06](#)})
- 33/04 . . . Windows
- 35/00 X-ray tubes**
- 35/02 . . . Details
- 35/025 . . . {X-ray tubes with structurally associated circuit elements}
- 35/04 . . . Electrodes {; Mutual position thereof; Constructional adaptations therefor}
- 35/045 {Electrodes for controlling the current of the cathode ray, e.g. control grids}
- 35/06 . . . Cathodes
- 35/064 {Details of the emitter, e.g. material or structure ([H01J 35/065](#) takes precedence)}
- 35/065 {Field emission, photo emission or secondary emission cathodes}
- 35/066 {Details of electron optical components, e.g. cathode cups}
- 35/08 . . . Anodes; Anti cathodes
- 35/10 Rotary anodes; Arrangements for rotating anodes; Cooling rotary anodes
- 35/101 {Arrangements for rotating anodes, e.g. supporting means, means for greasing, means for sealing the axle or means for shielding or protecting the driving}
- 35/1017 {Bearings for rotating anodes}
- 35/1024 {Rolling bearings}
- 35/103 {Magnetic bearings}
- 35/104 {Fluid bearings}
- 35/105 {Cooling of rotating anodes, e.g. heat emitting layers or structures}
- 35/106 {Active cooling, e.g. fluid flow, heat pipes}
- 35/107 {Cooling of the bearing assemblies}
- 35/108 {Substrates for and bonding of emissive target, e.g. composite structures}
- 35/112 {Non-rotating anodes ([H01J 35/12](#) takes precedence)}
- 35/116 {Transmissive anodes (acting as a window [H01J 35/186](#))}
- 35/12 Cooling non-rotary anodes
- 35/13 {Active cooling, e.g. fluid flow, heat pipes}
- 35/14 . . . Arrangements for concentrating, focusing, or directing the cathode ray
- 35/147 {Spot size control}
- 35/153 {Spot position control}
- 35/16 . . . Vessels; Containers; Shields associated therewith
- 35/165 {joining connectors to the tube}
- 35/18 . . . Windows
- 35/186 {used as targets or X-ray converters}
- 35/20 . . . Selection of substances for gas fillings; Means for obtaining or maintaining the desired pressure within the tube, e.g. by gettering
- 35/22 . . . specially designed for passing a very high current for a very short time, e.g. for flash operation
- 35/24 . . . Tubes wherein the point of impact of the cathode ray on the anode or anticathode is movable relative to the surface thereof
- 35/26 . . . by rotation of the anode or anticathode
- 35/28 . . . by vibration, oscillation, reciprocation, or swash-plate motion of the anode or anticathode
- 35/30 . . . by deflection of the cathode ray
- 35/305 {by using a rotating X-ray tube in conjunction therewith}
- 35/32 . . . Tubes wherein the X-rays are produced at or near the end of the tube or a part thereof which tube or part has a small cross-section to facilitate introduction into a small hole or cavity
- 37/00 Discharge tubes with provision for introducing objects or material to be exposed to the discharge, e.g. for the purpose of examination or processing thereof ([H01J 33/00](#), [H01J 40/00](#), [H01J 41/00](#), [H01J 47/00](#), [H01J 49/00](#) take precedence)**
- 37/02 . . . Details

- 37/023 . . {Means for mechanically adjusting components not otherwise provided for (mechanically adjusting from the outside of electron or ion-optical components [H01J 37/067](#); positioning the object or material [H01J 37/20](#); vacuum locks, means for obtaining or maintaining the desired pressure within the tube [H01J 37/18](#); other manipulating devices [H01L 21/48](#), [G21F](#))}
- 37/026 . . {Means for avoiding or neutralising unwanted electrical charges on tube components}
- 37/04 . . Arrangements of electrodes and associated parts for generating or controlling the discharge, e.g. electron-optical arrangement, ion-optical arrangement {(electron or ion-optical systems for localised treatment of materials [H01J 37/3007](#); discharge control means in gas filled discharge tubes [H01J 37/32009](#))}
- 37/045 . . . {Beam blanking or chopping, i.e. arrangements for momentarily interrupting exposure to the discharge}
- 37/05 . . . Electron or ion-optical arrangements for separating electrons or ions according to their energy {or mass}(particle separator tubes [H01J 49/00](#))
- 37/06 . . . Electron sources; Electron guns {(electron sources in general [H01J 1/02](#), [H01J 19/02](#); electron guns in general [H01J 3/02](#))}
- 37/061 {Electron guns using electron multiplication}
- 37/063 Geometrical arrangement of electrodes for beam-forming
- 37/065 Construction of guns or parts thereof ([H01J 37/067](#) - [H01J 37/077](#) take precedence)
- 37/067 Replacing parts of guns; Mutual adjustment of electrodes ([H01J 37/073](#) - [H01J 37/077](#) take precedence; vacuum locks [H01J 37/18](#))
- 37/07 Eliminating deleterious effects due to thermal effects or electric or magnetic fields ([H01J 37/073](#) - [H01J 37/077](#) take precedence)
- 37/073 Electron guns using field emission, photo emission, or secondary emission electron sources
- 37/075 Electron guns using thermionic emission from cathodes heated by particle bombardment or by irradiation, e.g. by laser
- 37/077 Electron guns using discharge in gases or vapours as electron sources
- 37/08 . . . Ion sources; Ion guns
- 37/09 . . . Diaphragms; Shields associated with electron or ion-optical arrangements; Compensation of disturbing fields
- 37/10 . . . Lenses
- 37/12 electrostatic
- 37/14 magnetic
- 37/141 Electromagnetic lenses
- 37/1413 {Means for interchanging parts of the lens, e.g. pole pieces, within the tube (mechanically adjusting electron (ion) optical components [H01J 37/15](#))}
- 37/1416 {with superconducting coils}
- 37/143 Permanent magnetic lenses
- 37/145 Combinations of electrostatic and magnetic lenses
- 37/147 . . . Arrangements for directing or deflecting the discharge along a desired path (([H01J 37/045](#) take precedence;) lenses [H01J 37/10](#))
- 37/1471 {for centering, aligning or positioning of ray or beam}
- 37/1472 {Deflecting along given lines}
- 37/1474 {Scanning means}
- 37/1475 {magnetic}
- 37/1477 {electrostatic}
- 37/1478 {Beam tilting means, i.e. for stereoscopy or for beam channelling}
- 37/15 External mechanical adjustment of electron or ion optical components ([H01J 37/067](#), [H01J 37/20](#) take precedence)
- 37/153 . . . Electron-optical or ion-optical arrangements for the correction of image defects, e.g. stigmators
- 37/16 . . Vessels; Containers
- 37/165 . . . {Means associated with the vessel for preventing the generation of or for shielding unwanted radiation, e.g. X-rays}
- 37/18 . . Vacuum locks {; Means for obtaining or maintaining the desired pressure within the vessel (vacuum locks for electron-beam tubes in general [H01J 29/865](#))}
- 37/185 . . . {Means for transferring objects between different enclosures of different pressure or atmosphere}
- 37/20 . . Means for supporting or positioning the objects or the material; Means for adjusting diaphragms or lenses associated with the support {(introducing the objects [H01J 37/18](#))}
- 37/21 . . Means for adjusting the focus {(adjusting the focus while observing the image by photographic or optical means [H01J 37/22](#); means for observing the object or the point of impact on the object in tubes for the localised treatment of materials [H01J 37/3005](#))}
- 37/22 . . Optical or photographic arrangements associated with the tube {(using a CRT for the display of the image in a scanning electron microscope [H01J 37/28](#); observing the object or the point of impact on the object in tubes for the localised treatment of materials [H01J 37/3007](#))}
- 37/222 . . . {Image processing arrangements associated with the tube (image data processing or generation, in general [G06T](#))}
- 37/224 . . . {Luminescent screens or photographic plates for imaging (photosensitive materials for photographic purposes [G03C](#)); Apparatus specially adapted therefor, e.g. cameras, TV-cameras, photographic equipment, exposure control; Optical subsystems specially adapted therefor, e.g. microscopes for observing image on luminescent screen}
- 37/226 . . . {Optical arrangements for illuminating the object; optical arrangements for collecting light from the object}
- 37/228 {whereby illumination and light collection take place in the same area of the discharge}
- 37/24 . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 37/241 . . . {High voltage power supply or regulation circuits (components [H01J 37/248](#))}

- 37/242 . . . {Filament heating power supply or regulation circuits ([H01J 37/241](#) takes precedence)}
- 37/243 . . . {Beam current control or regulation circuits ([H01J 37/241](#) takes precedence)}
- 37/244 . . Detectors; Associated components or circuits therefor
- 37/248 . . Components associated with high voltage supply {(means for measuring the high voltage *per se* [G01R 15/00](#))}
- 37/252 . . Tubes for spot-analysing by electron or ion beams; Microanalysers
- 37/256 . . using scanning beams
- 37/26 . . Electron or ion microscopes; Electron or ion diffraction tubes
- 37/261 . . {Details}
- 37/263 . . . {Contrast, resolution or power of penetration}
- 37/265 . . . {Controlling the tube; circuit arrangements adapted to a particular application not otherwise provided, e.g. bright-field-dark-field illumination}
- 37/266 . . {Measurement of magnetic- or electric fields in the object; Lorentz microscopy (emission microscopes [H01J 37/285](#); reflecting microscopes [H01J 37/29](#); spot analysing [H01J 37/252](#))}
- 37/268 . . . {with scanning beams}
- 37/27 . . Shadow microscopy
- 37/28 . . with scanning beams {([H01J 37/268](#), [H01J 37/292](#), [H01J 37/2955](#) take precedence)}
- 37/285 . . Emission microscopes, e.g. field-emission microscopes
- 37/29 . . Reflection microscopes
- 37/292 . . . {using scanning ray}
- 37/295 . . Electron or ion diffraction tubes
- 37/2955 . . . {using scanning ray}
- 37/30 . . Electron-beam or ion-beam tubes for localised treatment of objects
- 37/3002 . . {Details}
- 37/3005 . . . {Observing the objects or the point of impact on the object}
- 37/3007 . . . {Electron or ion-optical systems (electron or ion-optical details [H01J 37/06](#) - [H01J 37/153](#))}
- 37/301 . . Arrangements enabling beams to pass between regions of different pressure
- 37/302 . . Controlling tubes by external information, e.g. programme control ([H01J 37/304](#) takes precedence)
- 37/3023 . . . {Programme control}
- 37/3026 {Patterning strategy}
- 37/304 . . Controlling tubes by information coming from the objects {or from the beam}, e.g. correction signals
- 37/3045 . . . {Object or beam position registration}
- 37/305 . . for casting, melting, evaporating or etching {(methods for casting or melting of metals with electron beam or gas discharges [C22B 9/22](#))}
- 37/3053 . . . {for evaporating or etching}
- 37/3056 {for microworking, e.g. etching of gratings, trimming of electrical components (trimming of resistors [H01C 17/22](#))}
- 37/31 . . for cutting or drilling {(methods for cutting or drilling metals with electron beams [B23K 15/00](#))}
- 37/315 . . for welding {(methods for welding metals with electron beams [B23K 15/00](#))}
- 37/317 . . for changing properties of the objects or for applying thin layers thereon, e.g. for ion implantation ([H01J 37/36](#) takes precedence)
- 37/3171 . . . {for ion implantation (plasma immersion ion implantation [H01J 37/32412](#))}
- 37/3172 {Maskless patterned ion implantation}
- 37/3174 . . . {Particle-beam lithography, e.g. electron beam lithography}
- 37/3175 {Projection methods, i.e. transfer substantially complete pattern to substrate}
- 37/3177 {Multi-beam, e.g. fly's eye, comb probe}
- 37/3178 . . . {for applying thin layers on objects}
- 37/32 . . Gas-filled discharge tubes, {e.g. for surface treatment of objects such as coating, plating, etching, sterilising or bringing about chemical reactions}({general methods or devices for heat treatments of ferrous or non-ferrous metals or alloys by cathodic discharges [C21D 1/38](#); methods of carburising or nitriding of metals in general [C23C 8/00](#); methods for coating, plating or surface treating of or with metallic material [C23C 8/36](#), [C23C 14/32](#), [C23C 16/50](#); methods for coating, plating or surface treating of or with semiconductors [H01L 21/00](#);) heating by discharge [H05B](#))
- 37/32009 . . {Arrangements for generation of plasma specially adapted for examination or treatment of objects, e.g. plasma sources (plasma generation in general [H05H 1/24](#))}
- 37/32018 . . . {Glow discharge}
- 37/32027 {DC powered}
- 37/32036 {AC powered}
- 37/32045 {Circuits specially adapted for controlling the glow discharge}
- 37/32055 . . . {Arc discharge}
- 37/32064 {Circuits specially adapted for controlling the arc discharge (for plasma torches [H01H 1/36](#))}
- 37/32073 . . . {Corona discharge}
- 37/32082 . . . {Radio frequency generated discharge ([H01J 37/32357](#), [H01J 37/32366](#), [H01J 37/32394](#) and [H01J 37/32403](#) take precedence)}
- 37/32091 {the radio frequency energy being capacitively coupled to the plasma}
- 37/321 {the radio frequency energy being inductively coupled to the plasma}
- 37/3211 {Antennas, e.g. particular shapes of coils}
- 37/32119 {Windows}
- 37/32128 {using particular waveforms, e.g. polarised waves}
- 37/32137 {controlling of the discharge by modulation of energy}
- 37/32146 {Amplitude modulation, includes pulsing}
- 37/32155 {Frequency modulation}
- 37/32165 {Plural frequencies}
- 37/32174 {Circuits specially adapted for controlling the RF discharge}
- 37/32183 {Matching circuits, impedance matching circuits *per se* [H03H 7/38](#) and [H03H 7/40](#)}
- 37/32192 . . . {Microwave generated discharge ([H01J 37/32357](#), [H01J 37/32366](#), [H01J 37/32394](#), [H01J 37/32403](#) take precedence)}
- 37/32201 {Generating means}

- 37/32211 {Means for coupling power to the plasma}
- 37/3222 {Antennas}
- 37/32229 {Waveguides}
- 37/32238 {Windows}
- 37/32247 {Resonators}
- 37/32256 {Tuning means}
- 37/32266 {Means for controlling power transmitted to the plasma}
- 37/32275 {Microwave reflectors}
- 37/32284 {Means for controlling or selecting resonance mode}
- 37/32293 {using particular waveforms, e.g. polarised waves}
- 37/32302 {Plural frequencies}
- 37/32311 {Circuits specially adapted for controlling the microwave discharge}
- 37/32321 . . . {Discharge generated by other radiation ([H01J 37/32055](#), [H01J 37/32073](#), [H01J 37/32082](#), [H01J 37/32192](#), [H01J 37/32348](#) take precedence)}
- 37/3233 {using charged particles}
- 37/32339 {using electromagnetic radiation}
- 37/32348 . . . {Dielectric barrier discharge}
- 37/32357 . . . {Generation remote from the workpiece, e.g. down-stream}
- 37/32366 . . . {Localised processing}
- 37/32376 {Scanning across large workpieces}
- 37/32385 {Treating the edge of the workpieces}
- 37/32394 . . . {Treating interior parts of workpieces}
- 37/32403 . . . {Treating multiple sides of workpieces, e.g. 3D workpieces}
- 37/32412 . . . {Plasma immersion ion implantation}
- 37/32422 . . . {Arrangement for selecting ions or species in the plasma}
- 37/32431 . . {Constructional details of the reactor}
- 37/3244 . . . {Gas supply means}
- 37/32449 {Gas control, e.g. control of the gas flow}
- 37/32458 . . . {Vessel}
- 37/32467 {Material}
- 37/32477 {characterised by the means for protecting vessels or internal parts, e.g. coatings}
- 37/32486 {Means for reducing recombination coefficient}
- 37/32495 {Means for protecting the vessel against plasma}
- 37/32504 {Means for preventing sputtering of the vessel}
- 37/32513 {Sealing means, e.g. sealing between different parts of the vessel}
- 37/32522 {Temperature}
- 37/32532 . . . {Electrodes}
- 37/32541 {Shape}
- 37/3255 {Material}
- 37/32559 {Protection means, e.g. coatings}
- 37/32568 {Relative arrangement or disposition of electrodes; moving means}
- 37/32577 {Electrical connecting means}
- 37/32587 {Triode systems}
- 37/32596 {Hollow cathodes}
- 37/32605 {Removable or replaceable electrodes or electrode systems}
- 37/32614 {Consumable cathodes for arc discharge}
- 37/32623 . . . {Mechanical discharge control means}
- 37/32633 {Baffles}
- 37/32642 {Focus rings}
- 37/32651 {Shields, e.g. dark space shields, Faraday shields}
- 37/3266 . . . {Magnetic control means}
- 37/32669 {Particular magnets or magnet arrangements for controlling the discharge}
- 37/32678 {Electron cyclotron resonance}
- 37/32688 {Multi-cusp fields}
- 37/32697 . . . {Electrostatic control}
- 37/32706 {Polarising the substrate}
- 37/32715 . . . {Workpiece holder}
- 37/32724 {Temperature}
- 37/32733 . . . {Means for moving the material to be treated}
- 37/32743 {for introducing the material into processing chamber}
- 37/32752 {for moving the material across the discharge}
- 37/32761 {Continuous moving}
- 37/3277 {of continuous material}
- 37/32779 {of batches of workpieces}
- 37/32788 {for extracting the material from the process chamber}
- 37/32798 . . . {Further details of plasma apparatus not provided for in groups [H01J 37/3244](#) - [H01J 37/32788](#); special provisions for cleaning or maintenance of the apparatus}
- 37/32807 {Construction (includes replacing parts of the apparatus)}
- 37/32816 {Pressure}
- 37/32825 {Working under atmospheric pressure or higher}
- 37/32834 {Exhausting}
- 37/32844 {Treating effluent gases}
- 37/32853 {Hygiene}
- 37/32862 {*In situ* cleaning of vessels and/or internal parts}
- 37/32871 {Means for trapping or directing unwanted particles}
- 37/3288 {Maintenance}
- 37/32889 {Connection or combination with other apparatus}
- 37/32899 {Multiple chambers, e.g. cluster tools}
- 37/32908 {Utilities}
- 37/32917 . . {Plasma diagnostics}
- 37/32926 . . . {Software, data control or modelling}
- 37/32935 . . . {Monitoring and controlling tubes by information coming from the object and/or discharge}
- 37/32944 {Arc detection}
- 37/32954 {Electron temperature measurement}
- 37/32963 {End-point detection}
- 37/32972 {Spectral analysis}
- 37/32981 {Gas analysis}
- 37/3299 . . . {Feedback systems}
- 37/34 . . . operating with cathodic sputtering ([H01J 37/36](#) takes precedence (; methods of cathodic sputtering [C23C 14/34](#)))
- 37/3402 . . . {using supplementary magnetic fields}
- 37/3405 {Magnetron sputtering}
- 37/3408 {Planar magnetron sputtering}
- 37/3411 . . . {Constructional aspects of the reactor}

- 37/3414 {Targets}
- 37/3417 {Arrangements}
- 37/342 {Hollow targets}
- 37/3423 {Shape}
- 37/3426 {Material}
- 37/3429 {Plural materials}
- 37/3432 {Target-material dispenser}
- 37/3435 {Target holders (includes backing plates and endblocks)}
- 37/3438 {Electrodes other than cathode}
- 37/3441 {Dark space shields}
- 37/3444 {Associated circuits}
- 37/3447 {Collimators, shutters, apertures}
- 37/345 {Magnet arrangements in particular for cathodic sputtering apparatus (material of magnets or magnets in general [H01F 1/00](#), [H01F 7/00](#))}
- 37/3452 {Magnet distribution}
- 37/3455 {Movable magnets}
- 37/3458 {Electromagnets in particular for cathodic sputtering apparatus (electromagnets in general [H01F 7/06](#))}
- 37/3461 {Means for shaping the magnetic field, e.g. magnetic shunts}
- 37/3464 . . . {Operating strategies}
- 37/3467 {Pulsed operation, e.g. HIPIMS}
- 37/347 {Thickness uniformity of coated layers or desired profile of target erosion}
- 37/3473 {Composition uniformity or desired gradient}
- 37/3476 . . . {Testing and control}
- 37/3479 {Detecting exhaustion of target material}
- 37/3482 {Detecting or avoiding eroding through}
- 37/3485 {Means for avoiding target poisoning}
- 37/3488 . . . {Constructional details of particle beam apparatus not otherwise provided for, e.g. arrangement, mounting, housing, environment; special provisions for cleaning or maintenance of the apparatus}
- 37/3491 {Manufacturing of targets}
- 37/3494 {Adaptation to extreme pressure conditions}
- 37/3497 {Temperature of target}
- 37/36 . . . for cleaning surfaces while plating with ions of materials introduced into the discharge, e.g. introduced by evaporation {(condensing of electrically charged vapour onto a surface for covering materials with metals [C23C 14/32](#))}
- 40/00 Photoelectric discharge tubes not involving the ionisation of a gas ([H01J 49/00](#) takes precedence)**
- 40/02 . Details
- 40/04 . . Electrodes
- 40/06 . . . Photo-emissive cathodes
- 40/08 . . Magnetic means for controlling discharge
- 40/10 . . Selection of substances for gas fillings
- 40/12 . . One or more circuit elements structurally associated with the tube
- 40/14 . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 40/16 . . having photo- emissive cathode, e.g. alkaline photoelectric cell (operating with secondary emission [H01J 43/00](#))
- 40/18 . . with luminescent coatings for influencing the sensitivity of the tube, e.g. by converting the input wavelength
- 40/20 . . wherein a light-ray scans a photo-emissive screen
- 41/00 Discharge tubes for measuring pressure of introduced gas {or for detecting presence of gas}; Discharge tubes for evacuation by diffusion of ions**
- 41/02 . Discharge tubes for measuring pressure of introduced gas {or for detecting presence of gas}
- 41/04 . . with ionisation by means of thermionic cathodes
- 41/06 . . with ionisation by means of cold cathodes
- 41/08 . . with ionisation by means of radioactive substances, e.g. alphas
- 41/10 . . of particle spectrometer type (particle spectrometers per se [H01J 49/00](#))
- 41/12 . Discharge tubes for evacuating by diffusion of ions, e.g. ion pumps, getter ion pumps
- 41/14 . . with ionisation by means of thermionic cathodes
- 41/16 . . . using gettering substances
- 41/18 . . with ionisation by means of cold cathodes
- 41/20 . . . using gettering substances
- 43/00 Secondary-emission tubes; Electron-multiplier tubes (dynamic electron-multiplier tubes [H01J 25/76](#))**
- 43/02 . Tubes in which one or a few electrodes are secondary-electron emitting electrodes
- 43/025 . . {Circuits therefor}
- 43/04 . Electron multipliers {(if forming part of electron gun [H01J 3/023](#))}
- 43/045 . . {Position sensitive electron multipliers}
- 43/06 . . Electrode arrangements
- 43/08 . . . Cathode arrangements ({photo-emissive electrodes [H01J 1/34](#), [H01J 1/35](#)}; construction of photo cathodes [H01J 40/06](#), [H01J 40/16](#), [H01J 47/00](#), [H01J 49/08](#))
- 43/10 . . . Dynodes ([H01J 43/24](#), [H01J 43/26](#) take precedence)
- 43/12 . . . Anode arrangements
- 43/14 . . . Control of electron beam by magnetic field
- 43/16 . . . Electrode arrangements using essentially one dynode
- 43/18 . . . Electrode arrangements using essentially more than one dynode
- 43/20 Dynodes consisting of sheet material, e.g. plane, bent
- 43/22 Dynodes consisting of electron-permeable material, e.g. foil, grid, tube, venetian blind
- 43/24 Dynodes having potential gradient along their surfaces
- 43/243 {Dynodes consisting of a piling-up of channel-type dynode plates}
- 43/246 {Microchannel plates [MCP] (image amplification tubes using MCP [H01J 31/507](#))}
- 43/26 Box dynodes
- 43/28 . . Vessels {wall of the tube}; Windows; Screens; Suppressing undesired discharges or currents
- 43/30 . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for

- 45/00 Discharge tubes functioning as thermionic generators** [{\(structural combination of fuel element with thermoelectric element G21C 3/40; nuclear power plants using thermionic converters G21D 7/04; structural combination of a radioactive source with a thermionic converter, e.g. radioisotope batteries G21H 1/10; generators in which thermal or kinetic energy is converted into electrical energy by ionisation of a fluid and removal of the charge therefrom H02N 3/00\)}](#)
- 47/00 Tubes for determining the presence, intensity, density or energy of radiation or particles** [\({discharge tubes using igniting by associated radioactive materials or fillings, e.g. current stabilising tubes H01J 17/32} ; photoelectric discharge tubes not involving the ionisation of a gas H01J 40/00 {; discharge tubes for measuring the pressure, partial pressure of introduced gas or for detecting presence of gas H01J 41/02; ionisation chambers using a solid dielectric G01T 3/008}\)](#)
- 47/001 . {Details}
 - 47/002 . . {Vessels or containers}
 - 47/003 . . . {using tissue-equivalent materials}
 - 47/004 . . . {Windows permeable to X-rays, gamma-rays, or particles (windows for discharge tubes with provision for emergence of electrons or ions from the vessel H01J 33/04; windows for X-ray tubes H01J 35/18)}
 - 47/005 . . {Gas fillings (H01J 47/12 takes precedence); Maintaining the desired pressure within the tube}
 - 47/006 . . . {Tissue equivalent gas fillings}
 - 47/007 . {Flash detectors}
 - 47/008 . {Drift detectors}
 - 47/02 . Ionisation chambers
 - 47/022 . . {Calibration thereof}
 - 47/024 . . {Well-type ionisation chambers}
 - 47/026 . . {Gas flow ionisation chambers}
 - 47/028 . . {using a liquid dielectric}
 - 47/04 . . Capacitive ionisation chambers, e.g. the electrodes of which are used as electrometers
 - 47/06 . Proportional counter tubes
 - 47/062 . . {Multiwire proportional counter tubes}
 - 47/065 . . {Well-type proportional counter tubes}
 - 47/067 . . {Gas flow proportional counter tubes}
 - 47/08 . Geiger-Müller counter tubes [{\(gas filling with very short deionisation times H01J 17/64, H01T\)}](#)
 - 47/10 . Spark counters [\(H01J 47/14 takes precedence; spark gaps H01T\)](#)
 - 47/12 . Neutron detector tubes, e.g. BF₃ tubes
 - 47/1205 . . {using nuclear reactions of the type (n, alpha) in solid materials, e.g. Boron-10 (n,alpha) Lithium-7, Lithium-6 (n, alpha)Hydrogen-3}
 - 47/1211 . . . {Ionisation chambers}
 - 47/1216 {Gamma compensated}
 - 47/1222 . . . {Proportional counters}
 - 47/1227 . . {Fission detectors}
 - 47/1233 . . . {Ionisation chambers}
 - 47/1238 . . . {Counters}
 - 47/1244 {Multiwire counters}
 - 47/125 . . {Helium ionisation detectors}
 - 47/1255 . . . {Ionisation chambers}
 - 47/1261 . . . {Counters}
 - 47/1266 {Multi-wire counters}
 - 47/1272 . . {BF₃ tubes}
 - 47/1277 . . {Light-nuclei-recoil ionisation detectors, e.g. using protons, alpha-particles}
 - 47/1283 . . . {Ionisation chambers}
 - 47/1288 . . . {Counters}
 - 47/1294 {Multi-wire counters}
 - 47/14 . Parallel electrode spark or streamer chambers; Wire spark or streamer chambers [{\(circuit arrangements with multi-wire or parallel-plate chambers for recording of movements or tracks of particles G01T 5/12\)}](#)
 - 47/16 . . characterised by readout of each individual wire
 - 47/18 . . . the readout being electrical [\(H01J 47/20 takes precedence\)](#)
 - 47/20 . . . the readout employing electrical or mechanical delay lines, e.g. magnetostrictive delay lines
 - 47/22 . . characterised by another type of readout
 - 47/24 . . . the readout being acoustical
 - 47/26 . . . the readout being optical
- 49/00 Particle spectrometers or separator tubes**
- NOTE**
- In classifying particle separators, no distinction is made between spectrometry and spectrography, the difference being only in the manner of detection which in the first case is electrical and in the second case is by means of a photographic film.
- 49/0004 . {Imaging particle spectrometry}
 - 49/0009 . {Calibration of the apparatus}
 - 49/0013 . {Miniaturised spectrometers, e.g. having smaller than usual scale, integrated conventional components}
 - 49/0018 . . {Microminiaturised spectrometers, e.g. chip-integrated devices, MicroElectro-Mechanical Systems [MEMS]}
 - 49/0022 . {Portable spectrometers, e.g. devices comprising independent power supply, constructional details relating to portability [\(small scale devices per se H01J 49/0013 and H01J 49/0018\)](#)}
 - 49/0027 . {Methods for using particle spectrometers}
 - 49/0031 . . {Step by step routines describing the use of the apparatus [\(H01J 49/0081 takes precedence\)](#)}
 - 49/0036 . . {Step by step routines describing the handling of the data generated during a measurement [\(recognising patterns in signals G06K 9/00496\)](#)}
 - 49/004 . {Combinations of spectrometers, tandem spectrometers, e.g. MS/MS, MSn}
 - 49/0045 . . {characterised by the fragmentation or other specific reaction}
 - 49/005 . . . {by collision with gas, e.g. by introducing gas or by accelerating ions with an electric field}
 - 49/0054 . . . {by an electron beam, e.g. electron impact dissociation, electron capture dissociation}
 - 49/0059 . . . {by a photon beam, photo-dissociation}
 - 49/0063 . . . {by applying a resonant excitation voltage}
 - 49/0068 . . . {by collision with a surface, e.g. surface induced dissociation}
 - 49/0072 . . . {by ion/ion reaction, e.g. electron transfer dissociation, proton transfer dissociation}
 - 49/0077 . . . {specific reactions other than fragmentation}
 - 49/0081 . . {Tandem in time, i.e. using a single spectrometer}
 - 49/0086 . . {Accelerator mass spectrometers}

- 49/009 . . {Spectrometers having multiple channels, parallel analysis}
- 49/0095 . {Particular arrangements for generating, introducing or analyzing both positive and negative analyte ions (ion/ion reactions [H01J 49/0072](#))}
- 49/02 . Details
- 49/022 . . {Circuit arrangements, e.g. for generating deviation currents or voltages (regulating electric or magnetic variables in general, e.g. current, magnetic field [G05F](#)); Components associated with high voltage supply (high voltage supply [per se H02M](#))}
- 49/025 . . {Detectors specially adapted to particle spectrometers (data acquisition [H01J 49/0036](#); detectors [per se G01T](#), e.g. [G01T 1/28](#), [G01T 1/29](#))}
- 49/027 . . . {detecting image current induced by the movement of charged particles ([H01J 49/38](#) takes precedence)}
- 49/04 . . Arrangements for introducing or extracting samples to be analysed, e.g. vacuum locks; Arrangements for external adjustment of electron- or ion-optical components
- 49/0404 . . . {Capillaries used for transferring samples or ions (electrospray nozzles [H01J 49/167](#))}
- 49/0409 . . . {Sample holders or containers (containers for retaining a material to be analyzed, [B01L 3/50](#), for DNA, [C12Q 1/6834](#), for biological materials, [G01N 33/543](#))}
- 49/0413 {for automated handling}
- 49/0418 {for laser desorption, e.g. matrix-assisted laser desorption/ionisation [MALDI], surface enhanced laser desorption/ionisation [SELDI] plates}
- 49/0422 . . . {for gaseous samples (interfaces to gas chromatographs [G01N 30/7206](#))}
- 49/0427 {using a membrane permeable to gases}
- 49/0431 . . . {for liquid samples (interfaces to liquid chromatographs [G01N 30/7233](#))}
- 49/0436 {using a membrane permeable to liquids}
- 49/044 {with means for preventing droplets from entering the analyzer; Desolvation of droplets}
- 49/0445 {with means for introducing as a spray, a jet or an aerosol (electrospray ion sources [H01J 49/165](#))}
- 49/045 {with means for using a nebulising gas, i.e. pneumatically assisted}
- 49/0454 {with means for vaporising using mechanical energy, e.g. by ultrasonic vibrations}
- 49/0459 . . . {for solid samples}
- 49/0463 {Desorption by laser or particle beam, followed by ionisation as a separate step (sample holder [per se H01J 49/0418](#))}
- 49/0468 . . . {with means for heating or cooling the sample}
- 49/0472 {with means for pyrolysis}
- 49/0477 {using a hot fluid}
- 49/0481 {with means for collisional cooling}
- 49/0486 {with means for monitoring the sample temperature}
- 49/049 {with means for applying heat to desorb the sample; Evaporation}
- 49/0495 . . . {Vacuum locks; Valves (valves [per se F16K](#))}
- 49/06 . . Electron- or ion-optical arrangements
- 49/061 {Ion deflecting means, e.g. ion gates}
- 49/062 {Ion guides (linear ion traps performing mass selection [H01J 49/4225](#), mass filters [H01J 49/421](#))}
- 49/063 {Multipole ion guides, e.g. quadrupoles, hexapoles}
- 49/065 {having stacked electrodes, e.g. ring stack, plate stack}
- 49/066 {Ion funnels}
- 49/067 {Ion lenses, apertures, skimmers}
- 49/068 {Mounting, supporting, spacing, or insulating electrodes}
- 49/08 . . Electron sources, e.g. for generating photo-electrons, secondary electrons or Auger electrons
- 49/10 . . Ion sources; Ion guns
- 49/102 {using reflex discharge, e.g. Penning ion sources}
- 49/105 {using high-frequency excitation, e.g. microwave excitation, Inductively Coupled Plasma [ICP]}
- 49/107 {Arrangements for using several ion sources}
- 49/12 using an arc discharge, e.g. of the duoplasmatron type
- 49/123 {Duoplasmatrons}
- 49/126 {Other arc discharge ion sources using an applied magnetic field}
- 49/14 using particle bombardment, e.g. ionisation chambers
- 49/142 {using a solid target which is not previously vapourised}
- 49/145 {using chemical ionisation}
- 49/147 {with electrons, e.g. electron impact ionisation, electron attachment ([H01J 49/145](#) takes precedence)}
- 49/16 using surface ionisation, e.g. field-, thermionic- or photo-emission
- 49/161 {using photoionisation, e.g. by laser}
- 49/162 {Direct photo-ionisation, e.g. single photon or multi-photon ionisation}
- 49/164 {Laser desorption/ionisation, e.g. matrix-assisted laser desorption/ionisation [MALDI] (sample holders [H01J 49/0418](#))}
- 49/165 {Electrospray ionisation}
- 49/167 {Capillaries and nozzles specially adapted therefor; (electrostatic spraying [per se B05B 5/00](#))}
- 49/168 {field ionisation, e.g. corona discharge (atmospheric pressure corona discharge [per se H01T 19/00](#))}
- 49/18 using spark ionisation
- 49/20 . . Magnetic deflection
- 49/22 . . Electrostatic deflection
- 49/24 . . Vacuum systems, e.g. maintaining desired pressures
- 49/26 . Mass spectrometers or separator tubes
- 49/28 . . Static spectrometers
- 49/282 {using electrostatic analysers}
- 49/284 {using electrostatic and magnetic sectors with simple focusing, e.g. with parallel fields such as Aston spectrometer}

- 49/286 {with energy analysis, e.g. Castaing filter (in cathode-ray or electron-beam tubes [H01J 29/84](#); electron-or ion-optical arrangements for separating electrons or ions from an analysing or processing beam [H01J 37/05](#); micro- or spot-analysing tubes [H01J 37/252](#))}
- 49/288 {using crossed electric and magnetic fields perpendicular to the beam, e.g. Wien filter}
- 49/30 . . . using magnetic analysers {, e.g. Dempster spectrometer}
- 49/305 {with several sectors in tandem}
- 49/32 . . . using double focusing
- 49/322 {with a magnetic sector of 90 degrees, e.g. Mattauch-Herzog type}
- 49/324 {with an electrostatic section of 90 degrees, e.g. Nier-Johnson type}
- 49/326 {with magnetic and electrostatic sectors of 90 degrees}
- 49/328 {with a cycloidal trajectory by using crossed electric and magnetic fields, e.g. trochoidal type}
- 49/34 . . Dynamic spectrometers
- 49/36 . . . Radio frequency spectrometers, e.g. Bennett-type spectrometers, Redhead-type spectrometers
- 49/38 Omegatrons {Using ion cyclotron resonance}
- 49/40 . . . Time-of-flight spectrometers ([H01J 49/36 takes precedence](#))
- 49/401 {characterised by orthogonal acceleration, e.g. focusing or selecting the ions, pusher electrode}
- 49/403 {characterised by the acceleration optics and/or the extraction fields}
- 49/405 {characterised by the reflectron, e.g. curved field, electrode shapes}
- 49/406 {with multiple reflections (electrostatic traps [H01J 49/4245](#))}
- 49/408 {with multiple changes of direction, e.g. by using electric or magnetic sectors, closed-loop time-of-flight}
- 49/42 . . . Stability-of-path spectrometers, e.g. monopole, quadrupole, multipole, farvitrons
- 49/4205 {Device types}
- 49/421 {Mass filters, i.e. deviating unwanted ions without trapping}
- 49/4215 {Quadrupole mass filters ([H01J 49/4225 takes precedence](#))}
- 49/422 {Two-dimensional RF ion traps (ion guides without mass selection [H01J 49/062](#))}
- 49/4225 {Multipole linear ion traps, e.g. quadrupoles, hexapoles}
- 49/423 {with radial ejection}
- 49/4235 {Stacked rings or stacked plates}
- 49/424 {Three-dimensional ion traps, i.e. comprising end-cap and ring electrodes}
- 49/4245 {Electrostatic ion traps ([H01J 49/422 takes precedence](#); multi-reflection time of flight spectrometers [H01J 49/406](#))}
- 49/425 {with a logarithmic radial electric potential, e.g. orbitraps}
- 49/4255 {with particular constructional features}
- 49/426 {Methods for controlling ions}
- 49/4265 {Controlling the number of trapped ions, preventing space charge effects}
- 49/427 {Ejection and selection methods}
- 49/4275 {Applying a non-resonant auxiliary oscillating voltage, e.g. parametric excitation}
- 49/428 {Applying a notched broadband signal}
- 49/4285 {Applying a resonant signal, e.g. selective resonant ejection matching the secular frequency of ions ([H01J 49/429](#), [H01J 49/428 take precedence](#))}
- 49/429 {Scanning an electric parameter, e.g. voltage amplitude or frequency}
- 49/4295 {Storage methods}
- 49/44 . . Energy spectrometers, e.g. alpha-, beta-spectrometers
- 49/443 . . {Dynamic spectrometers}
- 49/446 . . . {Time-of-flight spectrometers}
- 49/46 . . Static spectrometers
- 49/463 . . . {using static magnetic fields}
- 49/466 . . . {using crossed electric and magnetic fields perpendicular to the beam, e.g. Wien filter ([see also H01J 49/288](#))}
- 49/48 . . . using electrostatic analysers, e.g. cylindrical sector, Wien filter
- 49/482 {with cylindrical mirrors}
- 49/484 {with spherical mirrors}
- 49/486 {with plane mirrors, i.e. uniform field}
- 49/488 {with retarding grids}

Discharge lamps

- 61/00 Gas-discharge or vapour-discharge lamps (arc lamps with consumable electrodes [H05B](#); electroluminescent lamps [H05B](#))**
- 61/02 . Details
- 61/025 . . {Associated optical elements}
- 61/04 . . Electrodes (for igniting [H01J 61/54](#)); Screens; Shields
- 61/045 . . . {Thermic screens or reflectors (heat-reflecting coatings on the wall of the vessel [H01J 61/35](#))}
- 61/06 . . . Main electrodes
- 61/067 for low-pressure discharge lamps
- 61/0672 {characterised by the construction of the electrode}
- 61/0675 {characterised by the material of the electrode}
- 61/0677 {characterised by the electron emissive material}
- 61/073 for high-pressure discharge lamps
- 61/0732 {characterised by the construction of the electrode}
- 61/0735 {characterised by the material of the electrode}
- 61/0737 {characterised by the electron emissive material}
- 61/09 Hollow cathodes
- 61/10 . . . Shields, screens, or guides for influencing the discharge
- 61/103 {Shields, screens or guides arranged to extend the discharge path ([H01J 61/106 takes precedence](#))}

- 61/106 {using magnetic means}
- 61/12 . . Selection of substances for gas fillings; Specified operating pressure or temperature
- 61/125 . . . {having an halogenide as principal component}
- 61/14 . . . having one or more carbon compounds as the principal constituents
- 61/16 . . . having helium, argon, neon, krypton, or xenon as the principle constituent
- 61/18 . . . having a metallic vapour as the principal constituent
- 61/20 mercury vapour
- 61/22 vapour of an alkali metal
- 61/24 . . Means for obtaining or maintaining the desired pressure within the vessel
- 61/26 . . . Means for absorbing or adsorbing gas, e.g. by gettering; Means for preventing blackening of the envelope
- 61/28 . . . Means for producing, introducing, or replenishing gas or vapour during operation of the lamp
- 61/30 . . Vessels; Containers
- 61/302 . . . {characterised by the material of the vessel}
- 61/305 . . . {Flat vessels or containers}
- 61/307 {with folded elongated discharge path}
- 61/32 . . . Special longitudinal shape, e.g. for advertising purposes {[H01J 61/305 takes precedence](#)}
- 61/322 {Circular lamps}
- 61/325 {U-shaped lamps}
- 61/327 {"Compact"-lamps, i.e. lamps having a folded discharge path}
- 61/33 . . . Special shape of cross-section, e.g. for producing cool spot
- 61/34 . . . Double-wall vessels or containers
- 61/35 . . . provided with coatings on the walls thereof; Selection of materials for the coatings {[using coloured coatings H01J 61/40](#); [using luminescent coatings H01J 61/42](#)}
- 61/36 . . Seals between parts of vessels; Seals for leading-in conductors; Leading-in conductors
- 61/361 . . . {Seals between parts of vessel}
- 61/363 {End-disc seals or plug seals}
- 61/365 {Annular seals disposed between the ends of the vessel {[H01J 61/363 takes precedence](#)}}
- 61/366 . . . {Seals for leading-in conductors}
- 61/368 {Pinched seals or analogous seals}
- 61/38 . . Devices for influencing the colour or wavelength of the light
- 61/40 . . . by light filters; by coloured coatings in or on the envelope
- 61/42 . . . by transforming the wavelength of the light by luminescence
- 61/44 Devices characterised by the luminescent material
- 61/46 Devices characterised by the binder or other non-luminescent constituent of the luminescent material, e.g. for obtaining desired pouring or drying properties
- 61/48 Separate coatings of different luminous materials
- 61/50 . . Auxiliary parts or solid material within the envelope for reducing risk of explosion upon breakage of the envelope, e.g. for use in mines
- 61/52 . . Cooling arrangements; Heating arrangements; Means for circulating gas or vapour within the discharge space {[heating or cooling arrangements to promote ionisation for starting H01J 61/54](#)}
- 61/523 . . . {Heating or cooling particular parts of the lamp}
- 61/526 {heating or cooling of electrodes}
- 61/54 . . Igniting arrangements, e.g. promoting ionisation for starting
- 61/541 . . . {using a bimetal switch}
- 61/542 {and an auxiliary electrode inside the vessel}
- 61/544 {and an auxiliary electrode outside the vessel}
- 61/545 . . . {using an auxiliary electrode inside the vessel {[H01J 61/542 takes precedence](#)}}
- 61/547 . . . {using an auxiliary electrode outside the vessel {[H01J 61/544 takes precedence](#)}}
- 61/548 . . . {using radioactive means to promote ionisation}
- 61/56 . . One or more circuit elements structurally associated with the lamp
- 61/58 . Lamps with both liquid anode and liquid cathode
- 61/60 . Lamps in which the discharge space is substantially filled with mercury before ignition
- 61/62 . Lamps with gaseous cathode, e.g. plasma cathode
- 61/64 . Cathode glow lamps
- 61/66 . . having one or more specially shaped cathodes, e.g. for advertising purposes {[alphanumeric](#)}
- 61/68 . Lamps in which the main discharge is between parts of a current-carrying guide, e.g. halo lamp
- 61/70 . Lamps with low-pressure unconstricted discharge {[having a cold pressure < 400 Torr](#)}
- 61/72 . . having a main light-emitting filling of easily vaporisable metal vapour, e.g. mercury
- 61/74 . . having a main light-emitting filling of difficult vaporisable metal vapour, e.g. sodium
- 61/76 . . having a filling of permanent gas or gases only
- 61/78 . . . with cold cathode; with cathode heated only by discharge, e.g. high-tension lamp for advertising
- 61/80 . . Lamps suitable only for intermittent operation, e.g. flash lamp
- 61/82 . Lamps with high-pressure unconstricted discharge {[having a cold pressure > 400 Torr](#)}
- 61/822 . . {High-pressure mercury lamps}
- 61/825 . . {High-pressure sodium lamps}
- 61/827 . . {Metal halide arc lamps}
- 61/84 . Lamps with discharge constricted by high pressure
- 61/86 . . with discharge additionally constricted by close spacing of electrodes, e.g. for optical projection
- 61/88 . . with discharge additionally constricted by envelope
- 61/90 . . Lamps suitable only for intermittent operation, e.g. flash lamp
- 61/92 . Lamps with more than one main discharge path
- 61/94 . . Paths producing light of different wavelengths, e.g. for simulating daylight
- 61/95 . Lamps with control electrode for varying intensity or wavelength of the light, e.g. for producing modulated light
- 61/96 . Lamps with light-emitting discharge path and separately-heated incandescent body within a common envelope, e.g. for simulating daylight

- 61/98 . Lamps with closely spaced electrodes heated to incandescence by light-emitting discharge, e.g. tungsten arc lamp
- 63/00 Cathode-ray or electron-stream lamps**
- 63/02 . Details, e.g. electrode, gas filling, shape of vessel
- 63/04 . . Vessels provided with luminescent coatings; Selection of materials for the coatings
- 63/06 . Lamps with luminescent screen excited by the ray or stream
- 63/08 . Lamps with gas plasma excited by the ray or stream
- 65/00 Lamps without any electrode inside the vessel; Lamps with at least one main electrode outside the vessel**
- 65/04 . Lamps in which a gas filling is excited to luminesce by an external electromagnetic field or by external corpuscular radiation, e.g. for indicating {[plasma display panels](#)}
- 65/042 . . {[by an external electromagnetic field](#)}
- 65/044 . . . {[the field being produced by a separate microwave unit](#)}
- 65/046 . . . {[the field being produced by using capacitive means around the vessel](#)}
- 65/048 . . . {[the field being produced by using an excitation coil](#)}
- 65/06 . Lamps in which a gas filling is excited to luminesce by radioactive material structurally associated with the lamp, e.g. inside the vessel
- 65/08 . Lamps in which a screen or coating is excited to luminesce by radioactive material located inside the vessel {[\(direct conversion of radiation energy from radioactive sources into light G21H 3/02\)](#)}
- 99/00 Subject matter not provided for in other groups of this subclass**
-
- 2201/00 Electrodes common to discharge tubes**
- 2201/02 . Arrangements for eliminating deleterious effects
- 2201/025 . . charging
- 2201/19 . Thermionic cathodes
- 2201/193 . . Thin film cathodes
- 2201/196 . . Emission assisted by other physical processes, e.g. field- or photo emission
- 2201/28 . Heaters for thermionic cathodes
- 2201/2803 . . Characterised by the shape or size
- 2201/2807 . . . Block
- 2201/281 . . . Cage-like construction
- 2201/2814 being a mesh-like network
- 2201/2817 . . . Rods
- 2201/2821 . . . Envelope or cross-section
- 2201/2825 being oval or elliptic
- 2201/2828 being rectangular or square
- 2201/2832 being circular
- 2201/2835 . . . Folded
- 2201/2839 Hair-pin or simple bend
- 2201/2842 . . . Conic
- 2201/2846 . . . Loop
- 2201/285 . . . Plurality of elements
- 2201/2853 . . . Serpentine
- 2201/2857 being coiled
- 2201/286 being looped
- 2201/2864 . . . Ribbon or bar
- 2201/2867 . . . Spiral or helix
- 2201/2871 being flattened
- 2201/2875 being double, reverse helix or interwoven
- 2201/2878 . . . Thin film or film-like
- 2201/2882 . . . Variable winding density
- 2201/2885 . . . Twisted
- 2201/2889 . . Characterised by material
- 2201/2892 . . Coatings
- 2201/2896 . . . Insulating layers
- 2201/30 . Cold cathodes
- 2201/304 . . Field emission cathodes
- 2201/30403 . . . characterised by the emitter shape
- 2201/30407 Microengineered point emitters
- 2201/30411 conical shaped, e.g. Spindt type
- 2201/30415 needle shaped
- 2201/30419 Pillar shaped emitters
- 2201/30423 Microengineered edge emitters
- 2201/30426 Coatings on the emitter surface, e.g. with low work function materials
- 2201/3043 Fibres
- 2201/30434 Nanotubes
- 2201/30438 Particles
- 2201/30442 Whiskers
- 2201/30446 . . . characterised by the emitter material
- 2201/30449 Metals and metal alloys
- 2201/30453 Carbon types
- 2201/30457 Diamond
- 2201/30461 Graphite
- 2201/30465 Fullerenes
- 2201/30469 Carbon nanotubes (CNTs)
- 2201/30473 Amorphous carbon
- 2201/30476 Diamond-like carbon [DLC]
- 2201/3048 Semiconductor materials
- 2201/30484 Carbides
- 2201/30488 Nitrides
- 2201/30492 Borides
- 2201/30496 Oxides
- 2201/306 . . Ferroelectric cathodes
- 2201/308 . . Semiconductor cathodes, e.g. having PN junction layers
- 2201/312 . . having an electric field perpendicular to the surface thereof
- 2201/3125 . . . Metal-insulator-Metal [MIM] emission type cathodes
- 2201/316 . . having an electric field parallel to the surface thereof, e.g. thin film cathodes
- 2201/3165 . . . Surface conduction emission type cathodes
- 2201/317 . . combined with other synergetic effects, e.g. secondary, photo- or thermal emission
- 2201/319 . . Circuit elements associated with the emitters by direct integration
- 2201/3195 . . . Resistive members, e.g. resistive layers
- 2201/32 . Secondary emission electrodes
- 2201/34 . Photoemissive electrodes
- 2201/342 . . Cathodes
- 2201/3421 . . . Composition of the emitting surface
- 2201/3423 Semiconductors, e.g. GaAs, NEA emitters
- 2201/3425 Metals, metal alloys
- 2201/3426 Alkaline metal compounds, e.g. Na-K-Sb
- 2201/3428 Organo-metallic compounds, e.g. Ferrocene

- 2203/00 Electron or ion optical arrangements common to discharge tubes or lamps**
- 2203/02 . Electron guns
 - 2203/0204 . . using cold cathodes, e.g. field emission cathodes
 - 2203/0208 . . . Control electrodes
 - 2203/0212 Gate electrodes
 - 2203/0216 characterised by the form or structure
 - 2203/022 Shapes or dimensions of gate openings
 - 2203/0224 Arrangement of gate openings
 - 2203/0228 Curved/extending upwardly
 - 2203/0232 characterised by the material
 - 2203/0236 Relative position to the emitters, cathodes or substrates
 - 2203/024 Focusing electrodes
 - 2203/0244 characterised by the form or structure
 - 2203/0248 Shapes or dimensions of focusing electrode openings
 - 2203/0252 Arrangement of focusing electrode openings
 - 2203/0256 characterised by the material
 - 2203/026 Relative position to the gateelectrodes, emitters, cathodes or substrates
 - 2203/0264 In the same plane as the gate electrodes or cathodes
 - 2203/0268 . . . Insulation layer
 - 2203/0272 for gate electrodes
 - 2203/0276 for focusing electrodes
 - 2203/028 characterised by the shape
 - 2203/0284 Dimensions of openings
 - 2203/0288 characterised by the material
 - 2203/0292 . . . Potentials applied to the electrodes
 - 2203/0296 . . Spin-polarised beams
 - 2203/04 . Ion guns
- 2209/00 Apparatus and processes for manufacture of discharge tubes**
- 2209/01 . Generalised techniques
 - 2209/012 . . Coating
 - 2209/015 . . . Machines therefor
 - 2209/017 . . Cleaning
 - 2209/02 . Manufacture of cathodes
 - 2209/022 . . Cold cathodes
 - 2209/0223 . . . Field emission cathodes
 - 2209/0226 Sharpening or reshaping of emitting point or edge
 - 2209/18 . Assembling together the component parts of the discharge tube
 - 2209/185 . . Machines therefor, e.g. electron gun assembling devices
 - 2209/236 . Manufacture of magnetic deflecting devices
 - 2209/2363 . . Coils
 - 2209/2366 . . . Machines therefor, e.g. winding, forming, welding, or the like
 - 2209/26 . Sealing parts of the vessel to provide a vacuum enclosure
 - 2209/261 . . Apparatus used for sealing vessels, e.g. furnaces, machines or the like
 - 2209/262 . . . means for applying sealing materials, e.g. frit paste dispensers
 - 2209/264 . . Materials for sealing vessels, e.g. frit glass compounds, resins or structures
 - 2209/265 . . Surfaces for sealing vessels
 - 2209/267 . . . shaped surfaces or flanges
 - 2209/268 . . . treated surfaces and surface preparations, e.g. to improve adhesion
 - 2209/38 . Control of maintenance of pressure in the vessel
 - 2209/383 . . Vacuum pumps
 - 2209/385 . . Gettering
 - 2209/3855 . . . Getter materials
 - 2209/387 . . Gas filling
 - 2209/389 . . Degassing
 - 2209/3893 . . . by a discharge
 - 2209/3896 . . . by heating
 - 2209/46 . Handling of tube components during manufacture
 - 2209/463 . . Identifying or selecting component pieces
 - 2209/466 . . . Marking, e.g. bar-codes
- 2211/00 Plasma display panels with alternate current induction of the discharge, e.g. AC-PDPs (plasma display panels making use of direct current H01J 2217/00)**
- 2211/10 . AC-PDPs with at least one main electrode being out of contact with the plasma
 - 2211/12 . . with main electrodes provided on both sides of the discharge space
 - 2211/14 . . with main electrodes provided only on one side of the discharge space
 - 2211/16 . . with main electrodes provided inside or on the side face of the spacers
 - 2211/18 . . containing a plurality of independent closed structures for containing the gas, e.g. plasma tube array [PTA] display panels
 - 2211/20 . Constructional details
 - 2211/22 . . Electrodes
 - 2211/225 . . . Material of electrodes
 - 2211/24 . . . Sustain electrodes or scan electrodes
 - 2211/245 Shape, e.g. cross section or pattern
 - 2211/26 . . . Address electrodes
 - 2211/265 Shape, e.g. cross section or pattern
 - 2211/28 . . . Auxiliary electrodes, e.g. priming electrodes or trigger electrodes
 - 2211/30 . . . Floating electrodes
 - 2211/32 . . . Disposition of the electrodes
 - 2211/323 Mutual disposition of electrodes
 - 2211/326 Disposition of electrodes with respect to cell parameters ([H01J 2211/323 takes precedence](#)), e.g. electrodes within the ribs
 - 2211/34 . . Vessels, containers or parts thereof, e.g. substrates
 - 2211/36 . . . Spacers, barriers, ribs, partitions or the like
 - 2211/361 characterized by the shape
 - 2211/363 Cross section of the spacers
 - 2211/365 Pattern of the spacers
 - 2211/366 characterized by the material
 - 2211/368 Dummy spacers, e.g. in a non display region
 - 2211/38 . . . Dielectric or insulating layers
 - 2211/40 . . . Layers for protecting or enhancing the electron emission, e.g. MgO layers
 - 2211/42 . . . Fluorescent layers
 - 2211/44 . . . Optical arrangements or shielding arrangements, e.g. filters or lenses
 - 2211/442 Light reflecting means; Anti-reflection means
 - 2211/444 Means for improving contrast or colour purity, e.g. black matrix or light shielding means

H01J

- 2211/446 Electromagnetic shielding means; Antistatic means
- 2211/448 Near infrared shielding means
- 2211/46 . . Connecting or feeding means, e.g. leading-in conductors
- 2211/48 . . Sealing, e.g. seals specially adapted for leading-in conductors
- 2211/50 . . Filling, e.g. selection of gas mixture
- 2211/52 . . Means for absorbing or adsorbing the gas mixture, e.g. by gettering
- 2211/54 . . Means for exhausting the gas
- 2211/62 . . Circuit arrangements ([circuits or methods for driving PDP's G09G 3/28](#))
- 2211/66 . . Cooling arrangements ([cooling or supporting means not being part of the tube H05K](#))
- 2217/00 Gas-filled discharge tubes ([H01J 2211/00 takes precedence](#))**
- 2217/04 . . Electrodes ([for display panels not making use of alternating current H01J 2217/492](#); [for discharge tubes in general H01J 2201/00](#))
- 2217/06 . . Cathodes
- 2217/062 thermionic
- 2217/065 heated by the discharge
- 2217/067 Cold cathodes
- 2217/10 . . Anodes
- 2217/12 . . Control electrodes
- 2217/38 . . Cold-cathode tubes
- 2217/40 . . Gas discharge switches
- 2217/402 Multiple switches
- 2217/4025 for addressing electro-optical devices, i.e. LCD's
- 2217/49 . . Display panels, e.g. not making use of alternating current ([H01J 2211/10 takes precedence](#))
- 2217/491 characterised by problems peculiar to plasma displays
- 2217/4915 Luminosity
- 2217/492 Details
- 2217/49207 Electrodes
- 2217/49214 Shape
- 2217/49221 Mutual disposition
- 2217/49228 Crossed electrodes
- 2217/49235 Side-by-side electrodes
- 2217/49242 Auxiliary electrodes
- 2217/4925 Mounting, supporting, spacing
- 2217/49257 Means for isolating electrodes from the discharge, e.g. dielectric layers
- 2217/49264 Vessels
- 2217/49271 Spacers between front and back panels
- 2217/49278 Coatings ([H01J 2217/49292 takes precedence](#))
- 2217/49285 Associated optical means ([combined with electromagnetic screens H01J 2217/49292](#))
- 2217/49292 Filters
- 2217/494 A.C. panels
- 2217/498 Hybrid panels (AC and DC)
- 2223/00 Details of transit-time tubes of the types covered by group [H01J 2225/00](#)**
- 2223/005 . . Cooling methods or arrangements
- 2223/02 . . Electrodes; Magnetic control means; Screens
- 2223/027 . . Collectors
- 2223/0275 Multistage collectors
- 2223/033 Collector cooling devices
- 2223/04 . . Cathodes
- 2223/05 having a cylindrical emissive surface, e.g. cathodes for magnetrons
- 2223/06 . . Electron or ion guns
- 2223/065 producing a solid cylindrical beam
- 2223/07 producing a hollow cylindrical beam
- 2223/075 Magnetron injection guns
- 2223/08 . . Focusing arrangements, e.g. for concentrating stream of electrons, for preventing spreading of stream
- 2223/083 Electrostatic focusing arrangements
- 2223/087 Magnetic focusing arrangements
- 2223/0873 with at least one axial- field reversal along the interaction space, e.g. P.P.M. focusing
- 2223/0876 with arrangements improving the linearity and homogeneity of the axial field, e.g. field straightener
- 2223/09 . . Electric system for directing or deflecting the discharge along a desired path, e.g. E-type
- 2223/10 . . Magnet systems for directing or deflecting the discharge along a desired path, e.g. a spiral path
- 2223/11 . . Means for reducing noise
- 2223/12 . . Vessels; Containers
- 2223/14 . . Leading-in arrangements; Seals therefor
- 2223/15 . . Means for preventing wave energy leakage structurally associated with tube leading-in arrangements, e.g. filters, chokes, attenuating devices
- 2223/16 . . Circuit elements, having distributed capacitance and inductance, structurally associated with the tube and interacting with the discharge
- 2223/165 . . Manufacturing processes or apparatus therefore
- 2223/18 . . Resonators
- 2223/20 Cavity resonators; Adjustment or tuning thereof
- 2223/207 Tuning of single resonator
- 2223/213 Simultaneous tuning of more than one resonator, e.g. resonant cavities of a magnetron
- 2223/22 Connections between resonators, e.g. strapping for connecting resonators of a magnetron
- 2223/24 . . Slow-wave structures, e.g. delay systems
- 2223/26 Helical slow-wave structures; Adjustment therefor
- 2223/27 Helix-derived slow-wave structures
- 2223/28 Interdigital slow-wave structures; Adjustment therefor
- 2223/30 Damping arrangements associated with slow-wave structures, e.g. for suppression of unwanted oscillations
- 2223/34 . . Circuit arrangements not adapted to a particular application of the tube and not otherwise provided for
- 2223/36 . . Coupling devices having distributed capacitance and inductance, structurally associated with the tube, for introducing or removing wave energy
- 2223/38 to or from the discharge
- 2223/40 to or from the interaction circuit
- 2223/42 the interaction circuit being a helix or a helix-derived slow- wave structure
- 2223/44 Rod-type coupling devices
- 2223/46 Loop coupling devices
- 2223/48 for linking interaction circuit with coaxial lines; Devices of the coupled helices type

- 2223/50 the interaction circuit being a helix or derived from a helix
- 2223/52 the coupled helices being disposed coaxially around one another
- 2223/54 . . Filtering devices preventing unwanted frequencies or modes to be coupled to, or out of, the interaction circuit; Prevention of high frequency leakage in the environment
- 2225/00 Transit-time tubes, e.g. Klystrons, travelling-wave tubes, magnetrons**
- 2225/005 . Gas-filled transit-time tubes
- 2225/02 . Tubes with electron stream modulated in velocity or density in a modulator zone and thereafter giving up energy in an inducing zone, the zones being associated with one or more resonators
- 2225/025 . . with an electron stream following a helical path
- 2225/04 . . Tubes having one or more resonators, without reflection of the electron stream, and in which the modulation produced in the modulator zone is mainly density modulation, e.g. Heaff tube
- 2225/06 . . Tubes having only one resonator, without reflection of the electron stream, and in which the modulation produced in the modulator zone is mainly velocity modulation, e.g. Lüdi-Klystron
- 2225/08 . . . with electron stream perpendicular to the axis of the resonator
- 2225/10 . . Klystrons, i.e. tubes having two or more resonators, without reflection of the electron stream, and in which the stream is modulated mainly by velocity in the zone of the input resonator
- 2225/11 . . . Extended interaction Klystrons
- 2225/12 . . . with pencil-like electron stream in the axis of the resonators
- 2225/14 . . . with tube-like electron stream coaxial with the axis of the resonators
- 2225/16 . . . with pencil-like electron stream perpendicular to the axis of the resonators
- 2225/18 . . . with radial or disc-like electron stream perpendicular to the axis of the resonators
- 2225/20 . . . having special arrangements in the space between resonators, e.g. resistive-wall amplifier tube, space-charge amplifier tube, velocity-jump tube
- 2225/22 . . Reflex Klystrons, i.e. tubes having one or more resonators, with a single reflection of the electron stream, and in which the stream is modulated mainly by velocity in the modulator zone
- 2225/24 . . . in which the electron stream is in the axis of the resonator or resonators and is pencil-like before reflection
- 2225/26 . . . in which the electron stream is coaxial with the axis of the resonator or resonators and is tube-like before reflection
- 2225/28 . . . in which the electron stream is perpendicular to the axis of the resonator or resonators and is pencil-like before reflection
- 2225/30 . . . in which the electron stream is perpendicular to the axis of the resonator or resonators and is radial or disc-like before reflection
- 2225/32 . . Tubes with plural reflection, e.g. Coetier tube
- 2225/34 . Travelling-wave tubes; Tubes in which a travelling wave is simulated at spaced gaps
- 2225/36 . . Tubes in which an electron stream interacts with a wave travelling along a delay line or equivalent sequence of impedance elements, and without magnet system producing an H-field crossing the E-field
- 2225/38 . . . the forward travelling wave being utilised
- 2225/40 . . . the backward travelling wave being utilised
- 2225/42 . . Tubes in which an electron stream interacts with a wave travelling along a delay line or equivalent sequence of impedance elements, and with a magnet system producing an H-field crossing the E-field
- 2225/44 . . . the forward travelling wave being utilised
- 2225/46 . . . the backward travelling wave being utilised
- 2225/48 . . Tubes in which two electron streams of different velocities interact with one another, e.g. electron-wave tube
- 2225/49 . . Tubes using the parametric principle, e.g. for parametric amplification
- 2225/50 . Magnetrons, i.e. tubes with a magnet system producing an H-field crossing the E-field
- 2225/52 . . with an electron space having a shape that does not prevent any electron from moving completely around the cathode or guide electrode
- 2225/54 . . . having only one cavity or other resonator, e.g. neutrode tube
- 2225/55 Coaxial cavity magnetrons
- 2225/56 with interdigital arrangements of anodes, e.g. turbator tube
- 2225/58 . . . having a number of resonators; having a composite resonator, e.g. a helix
- 2225/587 Multi-cavity magnetrons
- 2225/593 Rising-sun magnetrons
- 2225/60 . . with an electron space having a shape that prevents any electron from moving completely around the cathode or guide electrode; Linear magnetrons
- 2225/61 . Hybrid tubes, i.e. tubes comprising a klystron section and a travelling-wave section
- 2225/62 . Strophotrons, i.e. tubes with H-field crossing the E-field and functioning with plural reflection
- 2225/64 . Turbine tubes, i.e. tubes with H-field crossing the E-field and functioning with reversed cyclotron action
- 2225/66 . Tubes with electron stream crossing itself and thereby interacting or interfering with itself
- 2225/68 . Tubes specially designed to act as oscillator with positive grid and retarding field, e.g. for Barkhausen-Kurz oscillators
- 2225/70 . . with resonator having distributed inductance with capacitance, e.g. Pintsch tube
- 2225/72 . . in which a standing wave or a considerable part thereof is produced along an electrode, e.g. Clavier tube
- 2225/74 . Tubes specially designed to act as transit-time diode oscillators, e.g. monotron
- 2225/76 . Dynamic electron-multiplier tubes, e.g. Farnsworth multiplier tube, multipactor
- 2225/78 . Tubes with electron stream modulated by deflection in a resonator
- 2229/00 Details of cathode ray tubes or electron beam tubes (H01J 2329/00 takes precedence)**
- 2229/0007 . Elimination of unwanted or stray electromagnetic effects

- 2229/0015 . . Preventing or cancelling fields leaving the enclosure
- 2229/0023 . . . Passive means
- 2229/003 . . Preventing or cancelling fields entering the enclosure
- 2229/0038 . . . Active means
- 2229/0046 . . Preventing or cancelling fields within the enclosure
- 2229/0053 . . . Demagnetisation
- 2229/0061 . Cooling arrangements
- 2229/0069 . . Active means, e.g. fluid flow
- 2229/0076 . . . applied to the faceplate
- 2229/0084 Translucent coolant, e.g. flowing across faceplate
- 2229/0092 . . Passive means, e.g. fins, heat conductors
- 2229/07 . Shadow masks
- 2229/0705 . . Mounting arrangement of assembly to vessel
- 2229/0711 . . . Spring and plate (clip) type
- 2229/0716 . . Mounting arrangements of aperture plate to frame or vessel
- 2229/0722 . . Frame
- 2229/0727 . . Aperture plate
- 2229/0733 . . . characterised by the material
- 2229/0738 . . . Mitigating undesirable mechanical effects
- 2229/0744 Vibrations
- 2229/075 . . . Beam passing apertures, e.g. geometrical arrangements
- 2229/0755 characterised by aperture shape
- 2229/0761 Uniaxial masks having parallel slit apertures, i.e. Trinitron type
- 2229/0766 . . . Details of skirt or border
- 2229/0772 Apertures, cut-outs, depressions, or the like
- 2229/0777 . . . Coatings
- 2229/0783 improving thermal radiation properties
- 2229/0788 . . . Parameterised dimensions of aperture plate, e.g. relationships, polynomial expressions
- 2229/0794 . . Geometrical arrangements, e.g. curvature
- 2229/18 . Phosphor screens
- 2229/183 . . multi-layer
- 2229/186 . . Geometrical arrangement of phosphors
- 2229/48 . Electron guns
- 2229/4803 . . Electrodes
- 2229/4806 . . . Shield centering cups
- 2229/481 . . . Focusing electrodes
- 2229/4813 Pre-focusing
- 2229/4817 . . . Accelerating electrodes
- 2229/482 . . . Extraction grids
- 2229/4824 . . Constructional arrangements of electrodes
- 2229/4827 . . . Electrodes formed on surface of common cylindrical support
- 2229/4831 . . . Electrode supports
- 2229/4834 . . Electrical arrangements coupled to electrodes, e.g. potentials
- 2229/4837 . . . characterised by the potentials applied
- 2229/4841 Dynamic potentials
- 2229/4844 . . characterised by beam passing apertures or combinations
- 2229/4848 . . . Aperture shape as viewed along beam axis
- 2229/4851 trapezoidal
- 2229/4855 with rounded end or ends
- 2229/4858 parallelogram
- 2229/4862 square
- 2229/4865 rectangle
- 2229/4868 with rounded end or ends
- 2229/4872 circular
- 2229/4875 oval
- 2229/4879 non-symmetric about field scanning axis
- 2229/4882 non-symmetric about line scanning axis
- 2229/4886 polygonal
- 2229/4889 cross shaped
- 2229/4893 Interconnected apertures
- 2229/4896 complex and not provided for
- 2229/50 . . Plurality of guns or beams
- 2229/502 . . . Three beam guns, e.g. for colour CRTs
- 2229/505 . . . Arrays
- 2229/507 . . . Multi-beam groups, e.g. number of beams greater than number of cathodes
- 2229/56 . Correction of beam optics
- 2229/563 . . Aberrations by type
- 2229/5632 . . . Spherical
- 2229/5635 . . . Astigmatism
- 2229/5637 . . . Colour purity
- 2229/568 . . using supplementary correction devices
- 2229/5681 . . . magnetic
- 2229/5682 Permanently magnetised materials, e.g. permanent magnets
- 2229/5684 Magnetic materials, e.g. soft iron
- 2229/5685 Cross-arms field shaper
- 2229/5687 Auxiliary coils
- 2229/5688 Velocity modulation
- 2229/58 . Electron beam control inside the vessel
- 2229/581 . . by magnetic means
- 2229/582 . . by electrostatic means
- 2229/583 . . at the source
- 2229/5835 . . . cooperating with the electron gun
- 2229/585 . . at the screen
- 2229/587 . . between the source and the screen
- 2229/70 . Electron beam control outside the vessel
- 2229/703 . . by magnetic fields
- 2229/7031 . . . Cores for field producing elements, e.g. ferrite
- 2229/7032 . . . Conductor design and distribution
- 2229/7033 Winding
- 2229/7035 Wires and conductors
- 2229/7036 Form of conductor
- 2229/7037 flat, e.g. foil, or ribbon type
- 2229/7038 . . . Coil separators and formers
- 2229/86 . Vessels and containers
- 2229/8603 . . Neck or cone portions of the CRT vessel
- 2229/8606 . . . characterised by the shape
- 2229/8609 Non circular cross-sections
- 2229/8613 . . . Faceplates
- 2229/8616 . . . characterised by shape
- 2229/862 Parameterised shape, e.g. expression, relationship or equation
- 2229/8623 . . . Substrates
- 2229/8626 . . . Frames
- 2229/863 . Passive shielding means associated with the vessel
- 2229/8631 . . . Coatings
- 2229/8632 characterised by the material
- 2229/8633 . . . Meshes and patterns
- 2229/8634 . . . Magnetic shielding
- 2229/8635 . . . Antistatic shielding
- 2229/8636 . . . Electromagnetic shielding

- 2229/8637 . . Mechanical shielding, e.g. against water or abrasion
- 2229/8638 . . Ionising radiation shielding, e.g. X-rays
- 2229/87 . Means for avoiding vessel implosion
- 2229/875 . . Means substantially covering the output face, e.g. resin layers, protective panels
- 2229/88 . Coatings
- 2229/882 . . having particular electrical resistive or conductive properties
- 2229/885 . . having particular electrical insulation properties
- 2229/887 . . having particular X-ray shielding properties
- 2229/89 . Optical components associated with the vessel
- 2229/8901 . . Fixing of optical components to the vessel
- 2229/8903 . . Fibre optic components
- 2229/8905 . . Direction sensitive devices for controlled viewing angle
- 2229/8907 . . Image projection devices
- 2229/8909 . . Baffles, shutters, apertures or the like against external light
- 2229/8911 . . . Large-scale devices, e.g. foldable screens
- 2229/8913 . . Anti-reflection, anti-glare, viewing angle and contrast improving treatments or devices
- 2229/8915 . . . Surface treatment of vessel or device, e.g. controlled surface roughness
- 2229/8916 . . . inside the vessel
- 2229/8918 . . . by using interference effects
- 2229/892 . . . Effect varying over surface
- 2229/8922 . . . Apparatus attached to vessel and not integral therewith
- 2229/8924 . . having particular properties for protecting the vessel, e.g. against abrasion, water or shock
- 2229/8926 . . Active components, e.g. LCD's, indicators, illuminators and moving devices
- 2229/8928 . . Laser CRTs
- 2229/893 . . using lenses
- 2229/899 . . Photographic devices (permanent recording of images)
- 2229/92 . Means providing or assisting electrical connection with or within the tube
- 2229/922 . . within the tube
- 2229/925 . . associated with the high tension [HT], e.g. anode potentials
- 2229/927 . . associated with digital scanning
- 2229/94 . Means for obtaining or maintaining the desired pressure within the tube
- 2229/96 . Circuit elements other than coils, reactors or the like, associated with the tube
- 2229/962 . . associated with the HT
- 2229/964 . . associated with the deflection system
- 2229/966 . . associated with the gun structure
- 2229/968 . . . Resistors
- 2231/00 Cathode ray tubes or electron beam tubes**
([H01J 2329/00](#) takes precedence)
- 2231/12 . CRTs having luminescent screens
- 2231/121 . . Means for indicating the position of the beam, e.g. beam indexing
- 2231/123 . . . by direct current detection, e.g. collecting electrodes
- 2231/125 . . with a plurality of electron guns within the tube envelope
- 2231/1255 . . . two or more neck portions containing one or more guns
- 2231/50 . Imaging and conversion tubes
- 2231/50005 . . characterised by form of illumination
- 2231/5001 . . . Photons
- 2231/50015 Light
- 2231/50021 Ultra-violet
- 2231/50026 Infra-red
- 2231/50031 High energy photons
- 2231/50036 X-rays
- 2231/50042 . . . Particles
- 2231/50047 Charged particles
- 2231/50052 . . . Mechanical vibrations, e.g. sound
- 2231/50057 . . characterised by form of output stage
- 2231/50063 . . . Optical
- 2231/50068 . . . Electrical
- 2231/50073 Charge coupled device [CCD]
- 2231/50078 Resistive anode
- 2231/50084 using light or electron beam scanning
- 2231/50089 . . . Having optical stage before electrical conversion
- 2231/50094 Charge coupled device [CCD]
- 2231/501 . . including multiplication stage
- 2231/5013 . . . with secondary emission electrodes
- 2231/5016 Microchannel plates [MCP]
- 2231/503 . . with scanning or gating optics
- 2231/5033 . . . electrostatic
- 2231/5036 . . . magnetic
- 2231/505 . . with non-scanning optics
- 2231/5053 . . . electrostatic
- 2231/5056 . . . magnetic
- 2235/00 X-ray tubes**
- 2235/02 . Electrical arrangements
- 2235/023 . . Connecting of signals or tensions to or through the vessel
- 2235/0233 . . . High tension
- 2235/0236 . . . Indirect coupling, e.g. capacitive or inductive
- 2235/06 . Cathode assembly
- 2235/062 . . Cold cathodes
- 2235/064 . . Movement of cathode
- 2235/066 . . . Rotation
- 2235/068 . . Multi-cathode assembly
- 2235/08 . Targets (anodes) and X-ray converters
- 2235/081 . . Target material
- 2235/082 . . . Fluids, e.g. liquids, gases
- 2235/083 . . Bonding or fixing with the support or substrate
- 2235/084 . . . Target-substrate interlayers or structures, e.g. to control or prevent diffusion or improve adhesion
- 2235/085 . . Target treatment, e.g. ageing, heating
- 2235/086 . . Target geometry
- 2235/088 . . Laminated targets, e.g. plurality of emitting layers of unique or differing materials
- 2235/10 . Drive means for anode (target) substrate
- 2235/1006 . . Supports or shafts for target or substrate
- 2235/1013 . . . Fixing to the target or substrate
- 2235/102 . . . Materials for the shaft
- 2235/1026 . . Means (motors) for driving the target (anode)
- 2235/1033 . . . mounted within the vacuum vessel
- 2235/104 . . characterised by the shape
- 2235/1046 . . Bearings and bearing contact surfaces
- 2235/1053 . . . Retainers or races

- 2235/106 . . . Dynamic pressure bearings, e.g. helical groove type
 - 2235/1066 . . . Treated contact surfaces, e.g. coatings
 - 2235/1073 . . . Magnetic bearings
 - 2235/108 . . Lubricants
 - 2235/1086 . . . liquid metals
 - 2235/1093 . . Measures for preventing vibration
 - 2235/12 . . Cooling
 - 2235/1204 . . . of the anode
 - 2235/1208 . . . of the bearing assembly
 - 2235/1212 . . . of the cathode
 - 2235/1216 . . . of the vessel
 - 2235/122 . . . of the window
 - 2235/1225 . . characterised by method
 - 2235/1229 . . . employing layers with high emissivity
 - 2235/1233 characterised by the material
 - 2235/1237 Oxides
 - 2235/1241 Bonding layer to substrate
 - 2235/1245 Increasing emissive surface area
 - 2235/125 with interdigitated fins or slots
 - 2235/1254 with microscopic surface features
 - 2235/1258 Placing objects in close proximity
 - 2235/1262 Circulating fluids
 - 2235/1266 flow being via moving conduit or shaft
 - 2235/127 Control of flow
 - 2235/1275 characterised by the fluid
 - 2235/1279 Liquid metals
 - 2235/1283 in conjunction with extended surfaces (e.g. fins or ridges)
 - 2235/1287 Heat pipes
 - 2235/1291 Thermal conductivity
 - 2235/1295 Contact between conducting bodies
 - 2235/16 . . Vessels
 - 2235/161 . . . Non-stationary vessels
 - 2235/162 Rotation
 - 2235/163 . . . shaped for a particular application
 - 2235/164 Small cross-section, e.g. for entering in a body cavity
 - 2235/165 . . . Shielding arrangements
 - 2235/166 against electromagnetic radiation
 - 2235/167 against thermal (heat) energy
 - 2235/168 against charged particles
 - 2235/18 . . Windows, e.g. for X-ray transmission
 - 2235/183 . . . Multi-layer structures
 - 2235/20 . . Arrangements for controlling gases within the X-ray tube
 - 2235/205 . . . Gettering
 - 2237/00 Discharge tubes exposing object to beam, e.g. for analysis treatment, etching, imaging**
 - NOTES**
 - 1. For features of general interest which may be found in other types of discharge tubes, an indexing code corresponding to general schemes [H01J 2201/00](#) - [H01J 2203/00](#) is given, e.g. for cathodes, vessels, cooling means or the like
 - 2. Same rules apply for manufacturing procedures ([H01J 2209/00](#)), unless really specific to the tube concerned.
 - 3. The codes in this main group are grouped according to the following principle:
- 2237/002 . . Cooling arrangements (of objects being observed or treated [H01J 2237/2001](#))
 - 2237/004 . . Charge control of objects or beams
 - 2237/0041 . . . Neutralising arrangements
 - 2237/0042 Deflection of neutralising particles
 - 2237/0044 of objects being observed or treated
 - 2237/0045 using secondary electrons
 - 2237/0047 using electromagnetic radiations, e.g. UV, X-rays, light
 - 2237/0048 . . . Charging arrangements
 - 2237/006 . . Details of gas supplies, e.g. in an ion source, to a beam line, to a specimen or to a workpiece, ([H01J 37/3244](#) takes precedence; environmental cells for electron microscopes [H01J 2237/2003](#); microscopes with environmental specimen chamber [H01J 2237/2608](#))
 - 2237/02 . . Details
 - 2237/0203 . . . Protection arrangements
 - 2237/0206 Extinguishing, preventing or controlling unwanted discharges
 - 2237/0209 Avoiding or diminishing effects of eddy currents
 - 2237/0213 Avoiding deleterious effects due to interactions between particles and tube elements
 - 2237/0216 . . . Means for avoiding or correcting vibration effects
 - 2237/022 . . . Avoiding or removing foreign or contaminating particles, debris or deposits on sample or tube
 - 2237/0225 Detecting or monitoring foreign particles
 - 2237/024 . . . Moving components not otherwise provided for ([diaphragms H01J 2237/0458](#); [objects H01J 2237/202](#))
 - 2237/0245 Moving whole optical system relatively to object
 - 2237/026 . . Shields
 - 2237/0262 electrostatic
 - 2237/0264 magnetic
 - 2237/0266 electromagnetic
 - 2237/0268 Liner tubes
 - 2237/028 . . . Particle traps
 - 2237/03 . . Mounting, supporting, spacing or insulating electrodes
 - 2237/032 . . . Mounting or supporting
 - 2237/036 . . . Spacing
 - 2237/038 . . . Insulating
 - 2237/04 . . Means for controlling the discharge
 - 2237/041 . . . Beam polarising means
 - 2237/043 . . . Beam blanking
 - 2237/0432 High speed and short duration
 - 2237/0435 Multi-aperture
 - 2237/0437 Semiconductor substrate
 - 2237/045 . . . Diaphragms
 - 2237/0451 with fixed aperture
 - 2237/0453 multiple apertures
 - 2237/0455 with variable aperture

- 2237/0456 . . . Supports
- 2237/0458 movable, i.e. for changing between differently sized apertures
- 2237/047 . . Changing particle velocity
- 2237/0473 . . . accelerating
- 2237/04732 with magnetic means
- 2237/04735 with electrostatic means
- 2237/04737 radio-frequency quadrupole [RFQ]
- 2237/0475 . . . decelerating
- 2237/04753 with magnetic means
- 2237/04756 with electrostatic means
- 2237/049 . . Focusing means
- 2237/0492 . . . Lens systems ([individual lenses H01J 2237/10](#))
- 2237/04922 electromagnetic
- 2237/04924 electrostatic
- 2237/04926 combined
- 2237/04928 Telecentric systems
- 2237/05 . . Arrangements for energy or mass analysis
- 2237/053 . . electrostatic
- 2237/0535 . . . Mirror analyser
- 2237/055 . . magnetic
- 2237/057 . . Energy or mass filtering
- 2237/06 . . Sources
- 2237/061 . . Construction
- 2237/062 . . . Reducing size of gun
- 2237/063 . . Electron sources
- 2237/06308 . . . Thermionic sources
- 2237/06316 Schottky emission
- 2237/06325 . . . Cold-cathode sources
- 2237/06333 Photo emission
- 2237/06341 Field emission
- 2237/0635 Multiple source, e.g. comb or array
- 2237/06358 Secondary emission
- 2237/06366 Gas discharge electron sources
- 2237/06375 . . . Arrangement of electrodes
- 2237/06383 . . . Spin polarised electron sources
- 2237/06391 . . . Positron sources
- 2237/065 . . Source emittance characteristics
- 2237/0653 . . . Intensity
- 2237/0656 . . . Density
- 2237/08 . . Ion sources
- 2237/0802 . . . Field ionization sources
- 2237/0805 Liquid metal sources
- 2237/0807 Gas field ion sources [GFIS]
- 2237/081 . . . Sputtering sources
- 2237/0812 . . . Ionized cluster beam [ICB] sources
- 2237/0815 . . . Methods of ionisation
- 2237/0817 Microwaves
- 2237/082 Electron beam
- 2237/0822 . . . Multiple sources
- 2237/0825 for producing different ions simultaneously
- 2237/0827 for producing different ions sequentially
- 2237/083 . . Beam forming
- 2237/0835 . . . Variable cross-section or shape
- 2237/10 . . Lenses
- 2237/103 . . characterised by lens type
- 2237/1035 . . . Immersion lens
- 2237/12 . . electrostatic
- 2237/1202 . . . Associated circuits
- 2237/1205 . . . Microlenses
- 2237/1207 . . . Einzel lenses
- 2237/121 . . . characterised by shape
- 2237/1215 Annular electrodes
- 2237/14 . . magnetic
- 2237/1405 . . . Constructional details
- 2237/141 Coils ([superconducting H01J 2237/142](#))
- 2237/1415 Bores or yokes, i.e. magnetic circuit in general
- 2237/142 . . . with superconducting coils
- 2237/15 . . Means for deflecting or directing discharge
- 2237/1501 . . Beam alignment means or procedures
- 2237/1502 . . Mechanical adjustments
- 2237/1503 . . . Mechanical scanning
- 2237/1504 . . Associated circuits
- 2237/1505 . . Rotating beam around optical axis
- 2237/1506 . . Tilting or rocking beam around an axis substantially at an angle to optical axis
- 2237/1507 . . . dynamically, e.g. to obtain same impinging angle on whole area
- 2237/1508 . . Combined electrostatic-electromagnetic means
- 2237/151 . . Electrostatic means
- 2237/1512 . . . Travelling wave deflectors
- 2237/1514 . . . Prisms
- 2237/1516 . . . Multipoles
- 2237/1518 . . . for X-Y scanning
- 2237/152 . . Magnetic means
- 2237/1523 . . . Prisms
- 2237/1526 . . . For X-Y scanning
- 2237/153 . . Correcting image defects, e.g. stigmators
- 2237/1532 . . Astigmatism
- 2237/1534 . . Aberrations
- 2237/1536 . . Image distortions due to scanning
- 2237/1538 . . Space charge (Boersch) effect compensation ([neutralising means H01J 2237/0041](#))
- 2237/16 . . Vessels ([liner tubes H01J 2237/0268](#))
- 2237/162 . . Open vessel, i.e. one end sealed by object or workpiece
- 2237/164 . . Particle-permeable windows
- 2237/166 . . Sealing means
- 2237/18 . . Vacuum control means
- 2237/182 . . Obtaining or maintaining desired pressure
- 2237/1825 . . . Evacuating means
- 2237/184 . . Vacuum locks
- 2237/186 . . Valves
- 2237/188 . . Differential pressure
- 2237/20 . . Positioning, supporting, modifying or maintaining the physical state of objects being observed or treated
- 2237/2001 . . Maintaining constant desired temperature
- 2237/2002 . . Controlling environment of sample
- 2237/2003 . . . Environmental cells
- 2237/2004 Biological samples
- 2237/2005 . . Seal mechanisms
- 2237/2006 . . . Vacuum seals
- 2237/2007 . . Holding mechanisms
- 2237/2008 . . specially adapted for studying electrical or magnetical properties of objects
- 2237/201 . . for mounting multiple objects
- 2237/202 . . Movement
- 2237/20207 . . . Tilt
- 2237/20214 . . . Rotation
- 2237/20221 . . . Translation
- 2237/20228 Mechanical X-Y scanning

- 2237/20235 Z movement or adjustment
- 2237/20242 Eucentric movement
- 2237/2025 Sensing velocity of translation or rotation
- 2237/20257 Magnetic coupling
- 2237/20264 Piezoelectric devices
- 2237/20271 Temperature responsive devices
- 2237/20278 Motorised movement
- 2237/20285 computer-controlled
- 2237/20292 Means for position and/or orientation registration
- 2237/204 Means for introducing and/or outputting objects ([locks H01J 2237/184](#))
- 2237/206 Modifying objects while observing
- 2237/2062 Mechanical constraints
- 2237/2065 Temperature variations ([maintaining constant desired temperature H01J 2237/2001](#))
- 2237/2067 Surface alteration
- 2237/208 Elements or methods for movement independent of sample stage for influencing or moving or contacting or transferring the sample or parts thereof, e.g. probe needles or transfer needles in FIB/SEM systems
- 2237/21 Focus adjustment ([lenses H01J 2237/10](#))
- 2237/213 during electron or ion beam welding or cutting
- 2237/216 Automatic focusing methods
- 2237/22 Treatment of data ([mixing signals H01J 2237/24495](#))
- 2237/221 Image processing
- 2237/223 Fourier techniques
- 2237/225 Displaying image using synthesised colours
- 2237/226 Image reconstruction
- 2237/228 Charged particle holography
- 2237/244 Detection characterized by the detecting means
- 2237/24405 Faraday cages
- 2237/2441 Semiconductor detectors, e.g. diodes
- 2237/24415 X-ray
- 2237/2442 Energy-dispersive (Si-Li type) spectrometer
- 2237/24425 Wavelength-dispersive spectrometer
- 2237/2443 Scintillation detectors
- 2237/24435 Microchannel plates
- 2237/2444 Electron Multiplier
- 2237/24445 using avalanche in a gas
- 2237/2445 Photon detectors for X-rays, light, e.g. photomultipliers
- 2237/24455 Transmitted particle detectors
- 2237/2446 Position sensitive detectors
- 2237/24465 Sector detectors, e.g. quadrants
- 2237/2447 Imaging plates
- 2237/24475 Scattered electron detectors
- 2237/2448 Secondary particle detectors
- 2237/24485 Energy spectrometers
- 2237/2449 Detector devices with moving charges in electric or magnetic fields
- 2237/24495 Signal processing, e.g. mixing of two or more signals
- 2237/245 Detection characterised by the variable being measured
- 2237/24507 Intensity, dose or other characteristics of particle beams or electromagnetic radiation
- 2237/24514 Beam diagnostics including control of the parameter or property diagnosed ([H01J 2237/30472 takes precedence](#))
- 2237/24521 Beam diameter
- 2237/24528 Direction of beam or parts thereof in view of the optical axis, e.g. beam angle, angular distribution, beam divergence, beam convergence or beam landing angle on sample or workpiece ([means for deflecting or directing discharge H01J 2237/15](#))
- 2237/24535 Beam current
- 2237/24542 Beam profile
- 2237/2455 Polarisation (electromagnetic beams)
- 2237/24557 Spin polarisation (particles)
- 2237/24564 Measurements of electric or magnetic variables, e.g. voltage, current, frequency
- 2237/24571 Measurements of non-electric or non-magnetic variables
- 2237/24578 Spatial variables, e.g. position, distance
- 2237/24585 Other variables, e.g. energy, mass, velocity, time, temperature
- 2237/24592 Inspection and quality control of devices
- 2237/248 Components associated with the control of the tube
- 2237/2482 Optical means
- 2237/2485 Electric or electronic means
- 2237/2487 using digital signal processors
- 2237/25 Tubes for localised analysis using electron or ion beams
- 2237/2505 characterised by their application
- 2237/2511 Auger spectrometers
- 2237/2516 Secondary particles mass or energy spectrometry
- 2237/2522 of electrons (ESCA, XPS)
- 2237/2527 Ions [SIMS]
- 2237/2533 Neutrals [SNMS]
- 2237/2538 Low energy electron microscopy [LEEM]
- 2237/2544 Diffraction [LEED]
- 2237/255 Reflection diffraction [RHEED]
- 2237/2555 Microprobes, i.e. particle-induced X-ray spectrometry
- 2237/2561 electron
- 2237/2566 ion
- 2237/2572 proton
- 2237/2577 atomic
- 2237/2583 using tunnel effects, e.g. STM, AFM
- 2237/2588 Lorenz microscopy (magnetic field measurement)
- 2237/2594 Measuring electric fields or potentials
- 2237/26 Electron or ion microscopes
- 2237/2602 Details
- 2237/2605 operating at elevated pressures, e.g. atmosphere
- 2237/2608 with environmental specimen chamber ([environmental cells H01J 2237/2003](#))
- 2237/2611 Stereoscopic measurements and/or imaging
- 2237/2614 Holography or phase contrast, phase related imaging in general, e.g. phase plates
- 2237/2617 Comparison or superposition of transmission images; Moiré
- 2237/262 Non-scanning techniques
- 2237/2623 Field-emission microscopes
- 2237/2626 Pulsed source
- 2237/28 Scanning microscopes
- 2237/2801 Details
- 2237/2802 Transmission microscopes
- 2237/2803 characterised by the imaging method
- 2237/2804 Scattered primary beam
- 2237/2805 Elastic scattering

- 2237/2806 Secondary charged particle
- 2237/2807 X-rays
- 2237/2808 Cathodoluminescence
- 2237/2809 . . . characterised by the imaging problems involved
- 2237/281 Bottom of trenches or holes
- 2237/2811 Large objects
- 2237/2812 . . . Emission microscopes
- 2237/2813 . . . characterised by the application
- 2237/2814 Measurement of surface topography
- 2237/2815 Depth profile
- 2237/2816 Length
- 2237/2817 Pattern inspection
- 2237/2818 . . . Scanning tunnelling microscopes
- 2237/282 . . Determination of microscope properties
- 2237/2823 . . . Resolution
- 2237/2826 . . . Calibration ([for object processing apparatus H01J 2237/30433](#))
- 2237/285 . . Emission microscopes
- 2237/2852 . . . Auto-emission (i.e. field-emission)
- 2237/2855 . . . Photo-emission
- 2237/2857 . . . Particle bombardment induced emission
- 2237/30 . Electron or ion beam tubes for processing objects
- 2237/303 . . Electron or ion optical systems
- 2237/304 . . Controlling tubes
- 2237/30405 . . . Details
- 2237/30411 using digital signal processors [DSP]
- 2237/30416 Handling of data ([for lithography H01J 37/3174](#))
- 2237/30422 Data compression
- 2237/30427 using neural networks or fuzzy logic
- 2237/30433 . . . System calibration ([for microscopes H01J 2237/2826](#))
- 2237/30438 Registration
- 2237/30444 Calibration grids
- 2237/3045 Deflection calibration ([deflecting in general H01J 2237/15; specific to material treating H01J 2237/30483](#))
- 2237/30455 . . . Correction during exposure
- 2237/30461 pre-calculated
- 2237/30466 . . . Detecting endpoint of process ([for plasma apparatus H01J 37/32963, for sputtering apparatus H01J 37/3479](#))
- 2237/30472 . . . Controlling the beam
- 2237/30477 Beam diameter
- 2237/30483 Scanning
- 2237/30488 Raster scan
- 2237/30494 Vector scan
- 2237/31 . . Processing objects on a macro-scale
- 2237/3104 . . . Welding
- 2237/3109 . . . Cutting
- 2237/3114 . . . Machining
- 2237/3118 . . . Drilling
- 2237/3123 . . . Casting
- 2237/3128 . . . Melting
- 2237/3132 . . . Evaporating
- 2237/3137 Plasma-assisted co-operation
- 2237/3142 . . . Ion plating
- 2237/3146 Ion beam bombardment sputtering
- 2237/3151 . . . Etching
- 2237/3156 . . . Curing
- 2237/316 . . . Changing physical properties
- 2237/3165 Changing chemical properties
- 2237/317 . . Processing objects on a microscale
- 2237/31701 . . . Ion implantation
- 2237/31703 Dosimetry
- 2237/31705 Impurity or contaminant control
- 2237/31706 characterised by the area treated
- 2237/31708 unpatterned
- 2237/3171 patterned
- 2237/31711 using mask
- 2237/31713 Focused ion beam
- 2237/31732 . . . Depositing thin layers on selected microareas ([ion plating H01J 2237/3142](#))
- 2237/31733 using STM
- 2237/31735 . . . Direct-write microstructures
- 2237/31737 using ions
- 2237/31738 using STM
- 2237/3174 . . . Etching microareas
- 2237/31742 for repairing masks
- 2237/31744 introducing gas in vicinity of workpiece
- 2237/31745 for preparing specimen to be viewed in microscopes or analyzed in microanalysers
- 2237/31747 using STM
- 2237/31749 . . . Focused ion beam
- 2237/3175 . . . Lithography
- 2237/31752 using particular beams or near-field effects, e.g. STM-like techniques
- 2237/31754 using electron beams
- 2237/31755 using ion beams
- 2237/31757 hybrid, i.e. charged particles and light, X-rays, plasma
- 2237/31759 using near-field effects, e.g. STM
- 2237/31761 Patterning strategy
- 2237/31762 Computer and memory organisation
- 2237/31764 Dividing into sub-patterns
- 2237/31766 Continuous moving of wafer
- 2237/31767 Step and repeat
- 2237/31769 Proximity effect correction
- 2237/31771 using multiple exposure
- 2237/31772 Flood beam
- 2237/31774 Multi-beam
- 2237/31776 Shaped beam
- 2237/31777 by projection
- 2237/31779 from patterned photocathode
- 2237/31781 from patterned cold cathode
- 2237/31783 M-I-M cathode
- 2237/31784 Semiconductor cathode
- 2237/31786 Field-emitting cathode
- 2237/31788 through mask
- 2237/31789 Reflection mask
- 2237/31791 Scattering mask
- 2237/31793 Problems associated with lithography
- 2237/31794 affecting masks
- 2237/31796 affecting resists
- 2237/31798 detecting pattern defects ([with SEM H01J 2237/2817; correcting H01J 2237/31735, H01J 2237/3174](#))
- 2237/32 . Processing objects by plasma generation
- 2237/327 . . Arrangements for generating the plasma
- 2237/33 . . characterised by the type of processing
- 2237/332 . . . Coating
- 2237/3321 CVD [Chemical Vapor Deposition]
- 2237/3322 Problems associated with coating

H01J

- 2237/3323 uniformity
- 2237/3325 large area
- 2237/3326 high speed
- 2237/3327 Coating high aspect ratio workpieces
- 2237/3328 adhesion, stress, lift-off of deposited films
- 2237/334 . . . Etching
- 2237/3341 Reactive etching
- 2237/3342 Resist stripping
- 2237/3343 Problems associated with etching
- 2237/3344 isotropy
- 2237/3345 anisotropy
- 2237/3346 Selectivity
- 2237/3347 bottom of holes or trenches
- 2237/3348 control of ion bombardment energy
- 2237/335 Cleaning
- 2237/3355 Holes or apertures, i.e. inprinted circuit boards
- 2237/336 Changing physical properties of treated surfaces
- 2237/3365 Plasma source implantation
- 2237/338 Changing chemical properties of treated surfaces
- 2237/3382 Polymerising
- 2237/3385 Carburising
- 2237/3387 Nitriding
- 2237/339 Synthesising components
- 2329/0439 characterised by the emitter material
- 2329/0442 Metals or metal alloys
- 2329/0444 Carbon types
- 2329/0447 Diamond
- 2329/0449 Graphite
- 2329/0452 Fullerenes
- 2329/0455 Carbon nanotubes (CNTs)
- 2329/0457 Amorphous carbon
- 2329/046 Diamond-like carbon [DLC]
- 2329/0463 Semiconductor materials
- 2329/0465 Carbides
- 2329/0468 Nitrides
- 2329/0471 Borides
- 2329/0473 Oxides
- 2329/0476 Ferroelectric cathodes
- 2329/0478 Semiconductor cathodes, e.g. having PN junction layers
- 2329/0481 Cold cathodes having an electric field perpendicular to the surface thereof
([H01J 2329/0407](#) - [H01J 2329/0478](#) take precedence)
- 2329/0484 Metal-Insulator-Metal [MIM] emission type cathodes
- 2329/0486 Cold cathodes having an electric field parallel to the surface thereof, e.g. thin film cathodes
- 2329/0489 Surface conduction emission type cathodes
- 2329/0492 Cold cathodes combined with other synergetic effects, e.g. secondary, photo- or thermal emission
- 2329/0494 Circuit elements associated with the emitters by direct integration
- 2329/0497 Resistive members, e.g. resistive layers
- 2329/08 Anode electrodes
- 2329/18 Luminescent screens
- 2329/20 characterised by the luminescent material
- 2329/22 characterised by the binder or adhesive for securing the luminescent material to its support, e.g. substrate
- 2329/28 with protective, conductive or reflective layers
- 2329/30 Shape or geometrical arrangement of the luminescent material
- 2329/32 Means associated with discontinuous arrangements of the luminescent material
- 2329/323 Black matrix
- 2329/326 Color filters structurally combined with the luminescent material
- 2329/46 Arrangements of electrodes and associated parts for generating or controlling the electron beams
- 2329/4604 Control electrodes
- 2329/4608 Gate electrodes
- 2329/4613 characterised by the form or structure
- 2329/4617 Shapes or dimensions of gate openings
- 2329/4621 Arrangement of gate openings
- 2329/4626 Curved or extending upwardly
- 2329/463 characterised by the material
- 2329/4634 Relative position to the emitters, cathodes or substrates
- 2329/4639 Focusing electrodes
- 2329/4643 characterised by the form or structure
- 2329/4647 Shapes or dimensions of focusing electrode openings
- 2329/4652 Arrangement of focusing electrode openings

Details

2261/00 Gas- or vapour-discharge lamps

- 2261/02 . . . Details
- 2261/38 . . . Devices for influencing the colour or wavelength of the light
- 2261/385 . . . Non-chemical aspects of luminescent layers, e.g. thickness profile, shape and distribution of luminescent coatings

2329/00 Electron emission display panels, e.g. field emission display panels

- 2329/002 . . . Cooling means
- 2329/005 . . . Multi-directional displaying, i.e. with multiple display faces facing in different directions
- 2329/007 . . . Vacuumless display panels, i.e. with phosphor directly applied to emitter without intermediate vacuum space
- 2329/02 . . . Electrodes other than control electrodes
- 2329/04 . . . Cathode electrodes
- 2329/0402 . . . Thermionic cathodes
- 2329/0405 . . . Cold cathodes other than those covered by [H01J 2329/0407](#) - [H01J 2329/0492](#)
- 2329/0407 . . . Field emission cathodes
- 2329/041 characterised by the emitter shape
- 2329/0413 Microengineered point emitters
- 2329/0415 conical shaped, e.g. Spindt type
- 2329/0418 needle shaped
- 2329/0421 Pillar shaped emitters
- 2329/0423 Microengineered edge emitters
- 2329/0426 Coatings on the emitter surface, e.g. with low work function materials
- 2329/0428 Fibres
- 2329/0431 Nanotubes
- 2329/0434 Particles
- 2329/0436 Whiskers

2329/4656 characterised by the material	2893/0005 Fixing of electrodes
2329/466 Relative position to the gate electrodes, emitters, cathodes or substrates	2893/0006 Mounting
2329/4665 In the same plane as the gate electrodes or cathodes	2893/0007 Machines for assembly
2329/4669	. . Insulation layers	2893/0008 Supply leads; Electrode supports via rigid connection to vessel
2329/4673	. . . for gate electrodes	2893/0009 Electrode system pressing against vessel wall
2329/4678	. . . for focusing electrodes	2893/001	. . Non-constructive schematic arrangements
2329/4682	. . . characterised by the shape	2893/0011	. . Non-emitting electrodes
2329/4686 Dimensions of openings	2893/0012	. . Constructural arrangements
2329/4691	. . . characterised by the material	2893/0013	. . . Sealed electrodes
2329/4695	. . Potentials applied to the electrodes	2893/0015	. . . Non-sealed electrodes
2329/86	. Vessels	2893/0016 Planar grids
2329/8605	. . Front or back plates	2893/0017 Cylindrical, helical or annular grids
2329/861	. . . characterised by the shape	2893/0018 Bar or cage-like grids
2329/8615	. . . characterised by the material	2893/0019	. . . Chemical composition and manufacture
2329/862	. . Frames	2893/002 chemical
2329/8625	. . Spacing members	2893/0021 carbon
2329/863	. . . characterised by the form or structure	2893/0022 Manufacture
2329/8635 having a corrugated lateral surface	2893/0023 carbonising and other surface treatments
2329/864	. . . characterised by the material	2893/0024 Planar grids
2329/8645	. . . with coatings on the lateral surfaces thereof	2893/0025 by winding wire upon a support
2329/865	. . . Connection of the spacing members to the substrates or electrodes	2893/0026	. . . Machines for manufacture of grids or anodes
2329/8655 Conductive or resistive layers	2893/0027	. . . Mitigation of temperature effects
2329/866 Adhesives	2893/0029	. Electron beam tubes
2329/8665	. . . Spacer holding means	2893/003	. Tubes with plural electrode systems
2329/867	. . Seals between parts of vessels	2893/0031	. Tubes with material luminescing under electron bombardment
2329/8675	. . . Seals between the frame and the front and/or back plate	2893/0032	. Tubes with variable amplification factor
2329/868	. . Passive shielding means of vessels	2893/0033	. Vacuum connection techniques applicable to discharge tubes and lamps
2329/8685	. . . Antistatic shielding	2893/0034	. . Lamp bases
2329/869	. . . Electromagnetic shielding	2893/0035	. . . shaped as flat plates, in particular metallic
2329/8695	. . . Mechanical shielding, e.g. against water or abrasion	2893/0036	. . . having wires, ribbons or tubes placed between two vessel walls and being perpendicular to at least one of said walls
2329/88	. . Coatings on walls of the vessels (H01J 2329/18 , H01J 2329/868 , H01J 2329/89 take precedence)	2893/0037	. . Solid sealing members other than lamp bases
2329/89	. . Optical components structurally combined with the vessel	2893/0038	. . . Direct connection between two insulating elements, in particular via glass material
2329/892	. . . Anti-reflection, anti-glare, viewing angle and contrast improving means	2893/0039 Glass-to-glass connection, e.g. by soldering
2329/895	. . . Spectral filters	2893/004 Quartz-to-quartz connection
2329/897	. . . Lenses	2893/0041 Direct connection between insulating and metal elements, in particular via glass material
2329/90	. Leading-in arrangements; seals therefor	2893/0043 Glass-to-metal or quartz-to-metal, e.g. by soldering
2329/92	. Means forming part of the display panel for the purpose of providing electrical connection to it	2893/0044 Direct connection between two metal elements, in particular via material a connecting material
2329/94	. Means for exhausting the vessel or maintaining vacuum within the vessel	2893/0045	. . Non-solid connections, e.g. liquid or rubber
2329/941	. . Means for exhausting the vessel	2893/0046	. . Lamp base with closure
2329/943	. . Means for maintaining vacuum within the vessel	2893/0047	. . Closure other than lamp base
2329/945	. . . by gettering	2893/0048	. Tubes with a main cathode
2329/946 characterised by the position or form of the getter	2893/0049	. . Internal parts
2329/948 characterised by the material of the getter	2893/005	. . Cathodes
2329/96	. Circuit elements structurally associated with the display panels (H01J 2329/0494 takes precedence)	2893/0051	. . Anode assemblies; screens for influencing the discharge
2893/00	Discharge tubes and lamps	2893/0052	. . . Anode supporting means
2893/0001	. Electrodes and electrode systems suitable for discharge tubes or lamps	2893/0053	. . . Leading in for anodes; Protecting means for anode supports
2893/0002	. . Construction arrangements of electrode systems	2893/0054	. . . Cooling means
2893/0003	. . . Anodes forming part of vessel walls	2893/0055	. . Movable screens
2893/0004 Anodes formed in central part	2893/0056	. . Parts inside tubes brought to incandescence by the discharge
		2893/0058	. . Grids; Auxiliary internal or external electrodes

- 2893/0059 . Arc discharge tubes
- 2893/006 . Tubes with electron bombarded gas (e.g. with plasma filter)
- 2893/0061 . Tubes with discharge used as electron source
- 2893/0062 . Tubes with temperature ionized gas as electron source
- 2893/0063 . Plasma light sources
- 2893/0064 . Tubes with cold main electrodes (including cold cathodes)
- 2893/0065 . . Electrode systems
- 2893/0066 . . . Construction, material, support, protection and temperature regulation of electrodes; Electrode cups
- 2893/0067 . . . Electrode assembly without control electrodes, e.g. including a screen
- 2893/0068 . . . electrode assembly with control electrodes, e.g. including a screen
- 2893/0069 . Tubes for displaying characters
- 2893/007 . Sequential discharge tubes
- 2893/0072 . Disassembly or repair of discharge tubes
- 2893/0073 . . Discharge tubes with liquid poolcathodes; constructional details
- 2893/0074 . . . Cathodic cups; Screens; Reflectors; Filters; Windows; Protection against mercury deposition; Returning condensed electrode material to the cathodic cup; Liquid electrode level control
- 2893/0075 Cathodic cups
- 2893/0076 Liquid electrode materials
- 2893/0077 Cathodic cup construction; Cathodic spot control
- 2893/0078 Mounting cathodic cups in the discharge tube
- 2893/0079 Means for limiting the cathodic spot movement
- 2893/008 Means for stabilising the cathodic spot
- 2893/0081 Cooling means
- 2893/0082 Returning condensed electrode material to the cathodic cup, e.g. including cleaning
- 2893/0083 Liquid electrode level control
- 2893/0084 Protection against mercury deposition
- 2893/0086 Gas fill; Maintaining or maintaining desired pressure; Producing, introducing or replenishing gas or vapour during operation of the tube; Getters; Gas cleaning; Electrode cleaning
- 2893/0087 Igniting means; Cathode spot maintaining or extinguishing means
- 2893/0088 . . Tubes with at least a solid principal cathode and solid anodes
- 2893/0089 . . . Electrode systems
- 2893/009 . . . Anode systems; Screens
- 2893/0091 Anode supporting means
- 2893/0092 Anodic screens or grids
- 2893/0093 Anodic arms
- 2893/0094 . . . Electrode arrangements; Auxiliary electrodes
- 2893/0095 . . Tubes with exclusively liquid main electrodes
- 2893/0096 . Transport of discharge tube components during manufacture, e.g. wires, coils, lamps, contacts, etc.
- 2893/0097 . . Incandescent wires of coils
- 2893/0098 . . Vessels